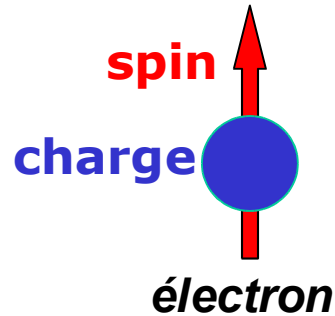
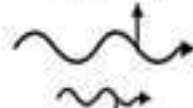


The origin, the development and the future of spintronics



Influence of spin on conduction

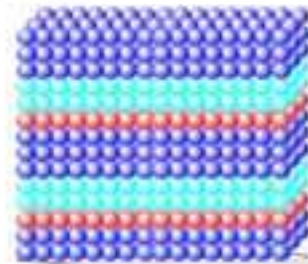
Spin up electron



Spin down electron



+ Magnetic nanostructures



→ Spintronics



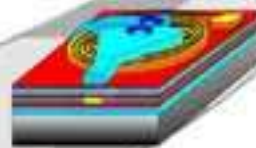
GMR, TMR, etc...

Magnetic switching and microwave generation by spin transfer, spintronics with semiconductors, molecular spintronics, etc

Memory (M-RAM)

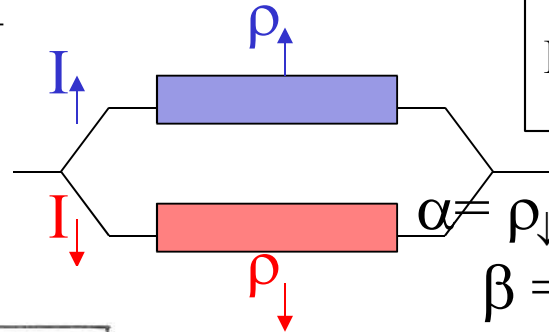
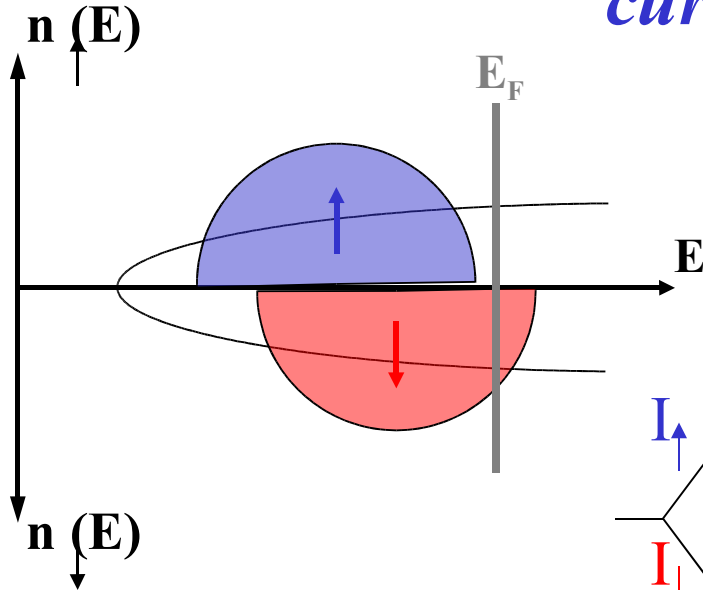


Read heads, sensors, etc.



Spin dependent conduction in ferromagnetic metals

current model)



Mott, Proc.Roy.Soc A153, 1936

Fert et al, PRL 21, 1190, 1968

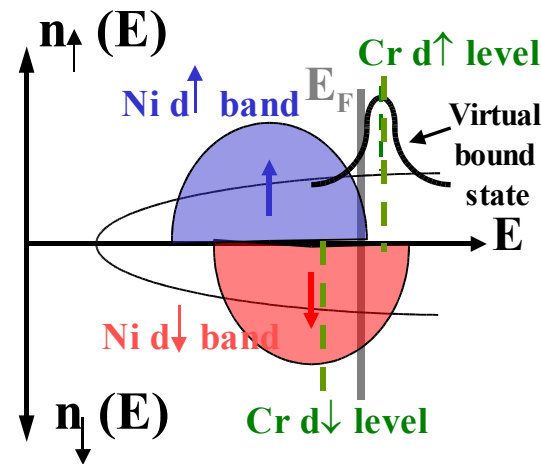
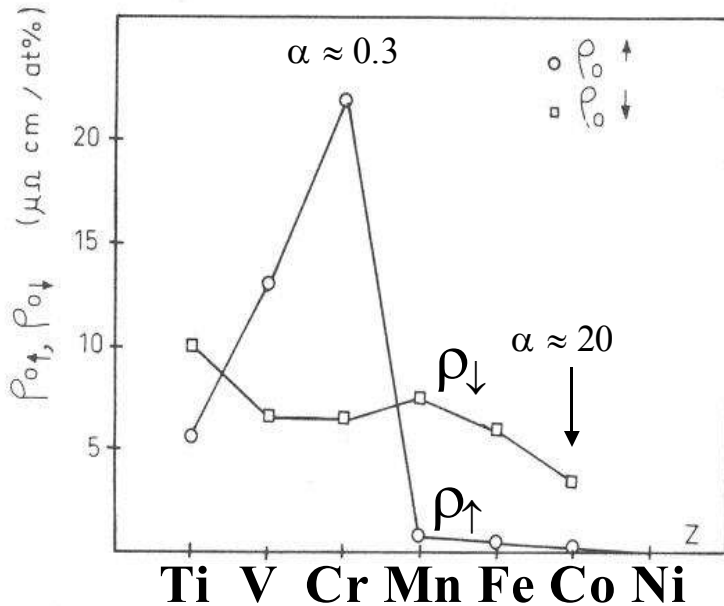
Loegel-Gautier, JPCS 32, 1971

Fert et al, J.Phys.F6, 849, 1976

Dorlejin et al, ibid F7, 23, 1977

$$\alpha = \rho_{\downarrow} / \rho_{\uparrow} \text{ or}$$

$$\beta = (\rho_{\downarrow} - \rho_{\uparrow}) / (\rho_{\downarrow} + \rho_{\uparrow}) = (\alpha - 1) / (\alpha + 1)$$



Mixing impurities A and B with opposite or similar spin asymmetries: *the pre-concept of GMR*

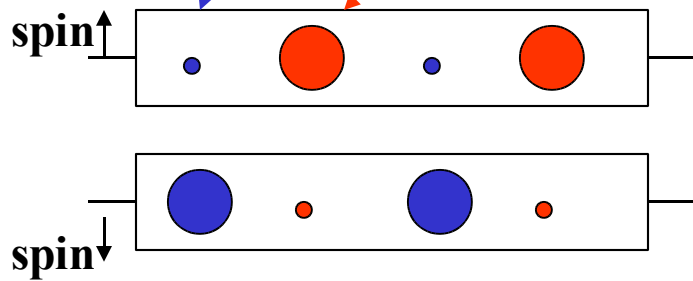
Example: Ni + impurities A and B (Fert-Campbell, 1968, 1971)

1st case
 $\alpha = \rho_{\downarrow} / \rho_{\uparrow}$
case

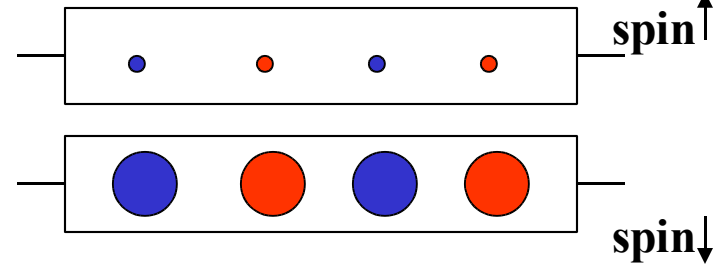
2d

$\alpha_A > 1, \alpha_B < 1$

α_A and $\alpha_B > 1$

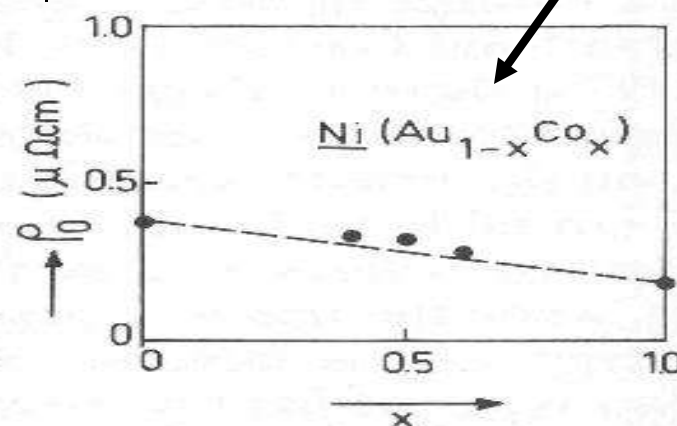
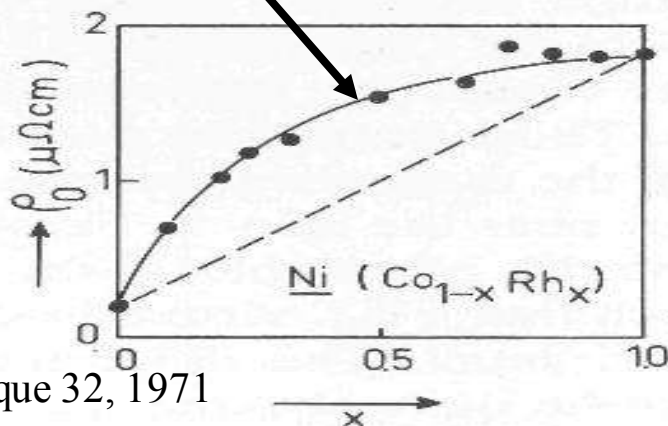


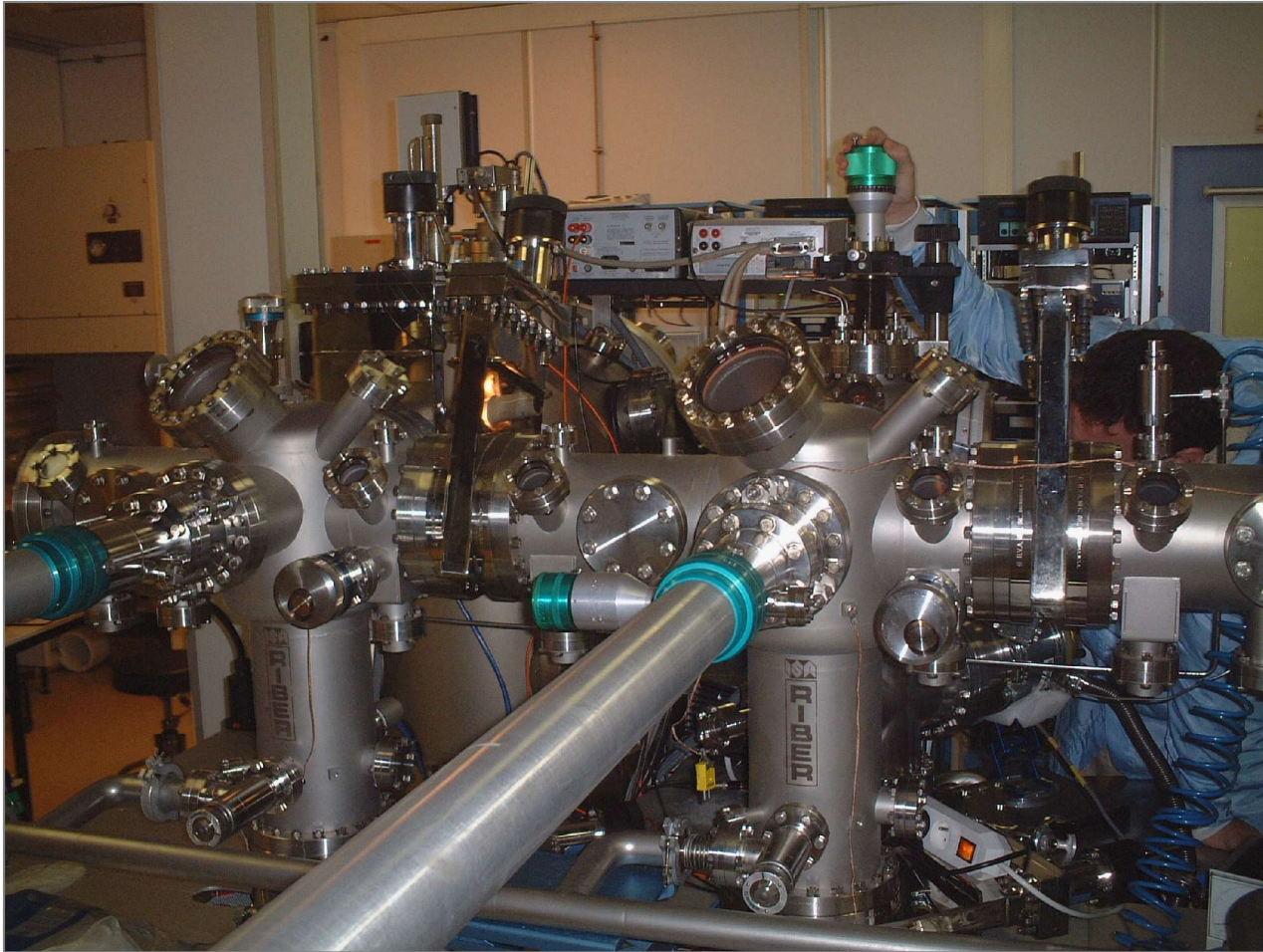
High mobility channel → low ρ



$\rho_{AB} \gg \rho_A + \rho_B$

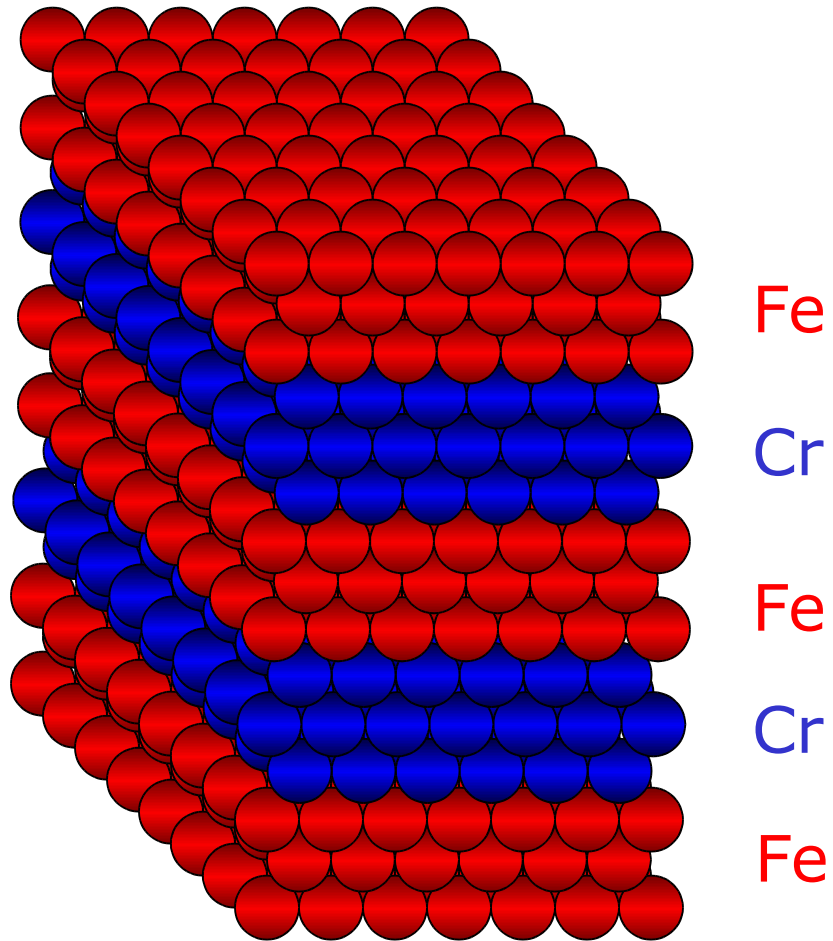
$\rho_{AB} \approx \rho_A + \rho_B$



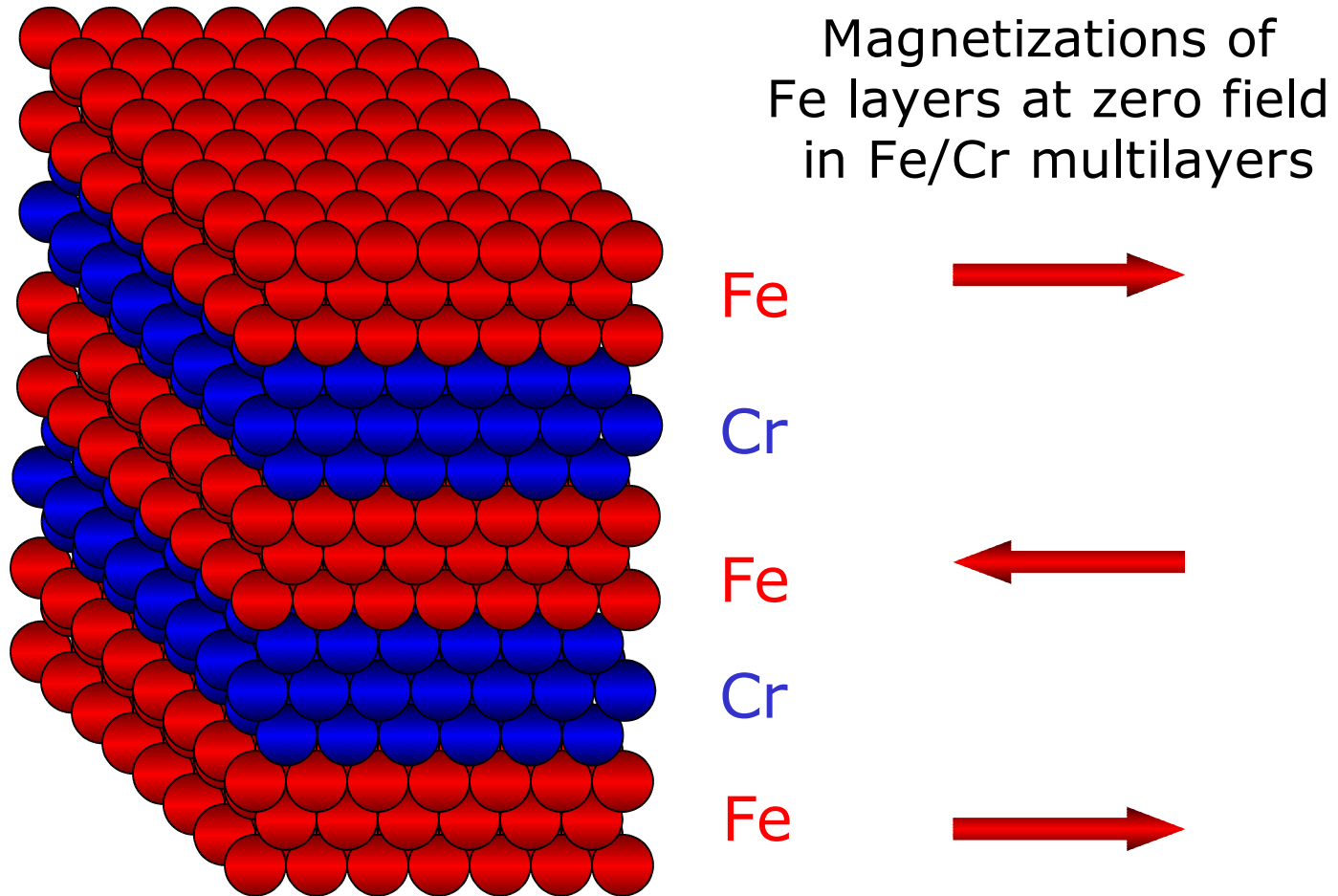


Molecular Beam Epitaxy
(growth of metallic multilayers)

- **Magnetic multilayers**

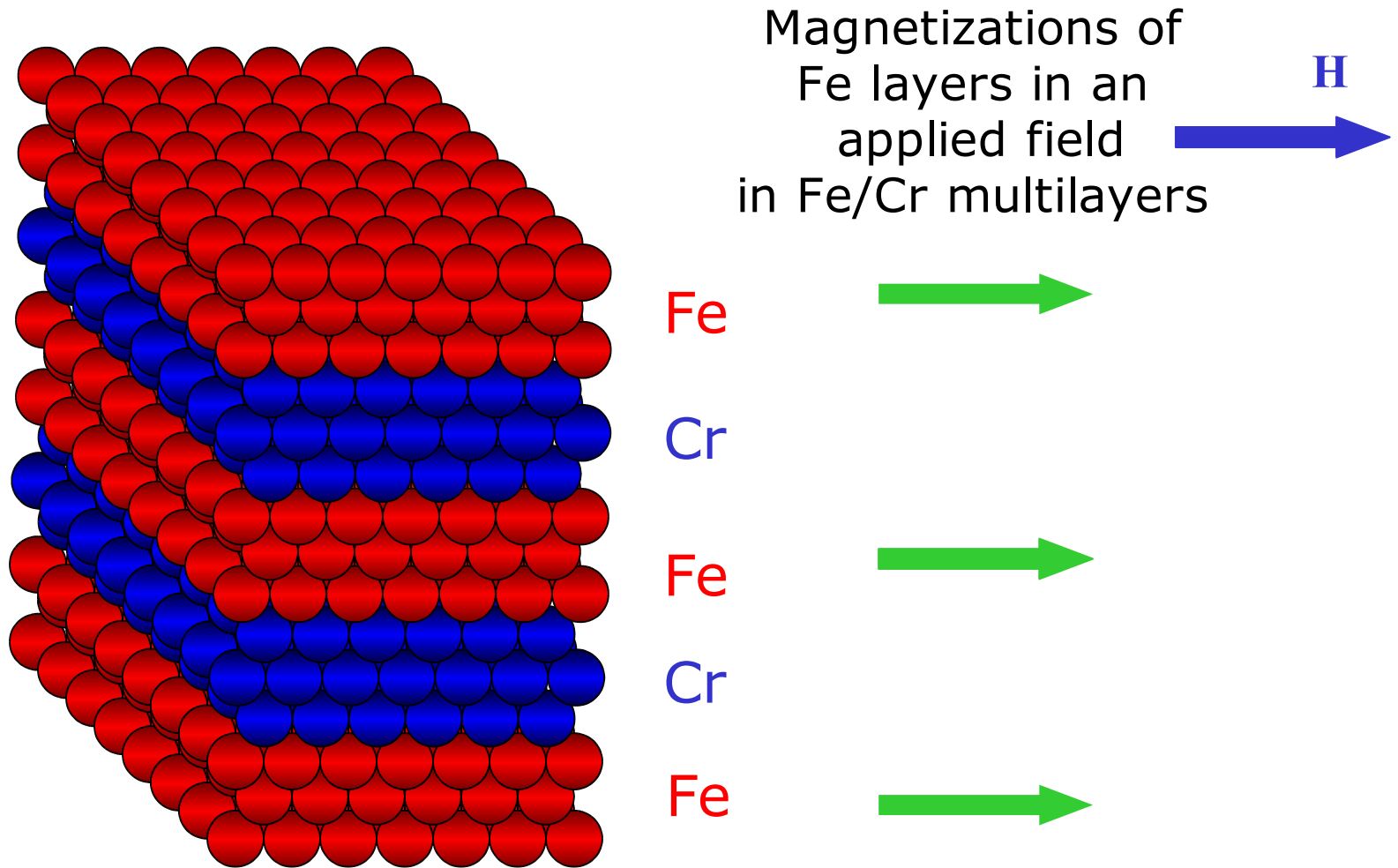


- **Magnetic multilayers**



P. Grünberg, 1986 → antiferromagnetic interlayer coupling

- **Magnetic multilayers**

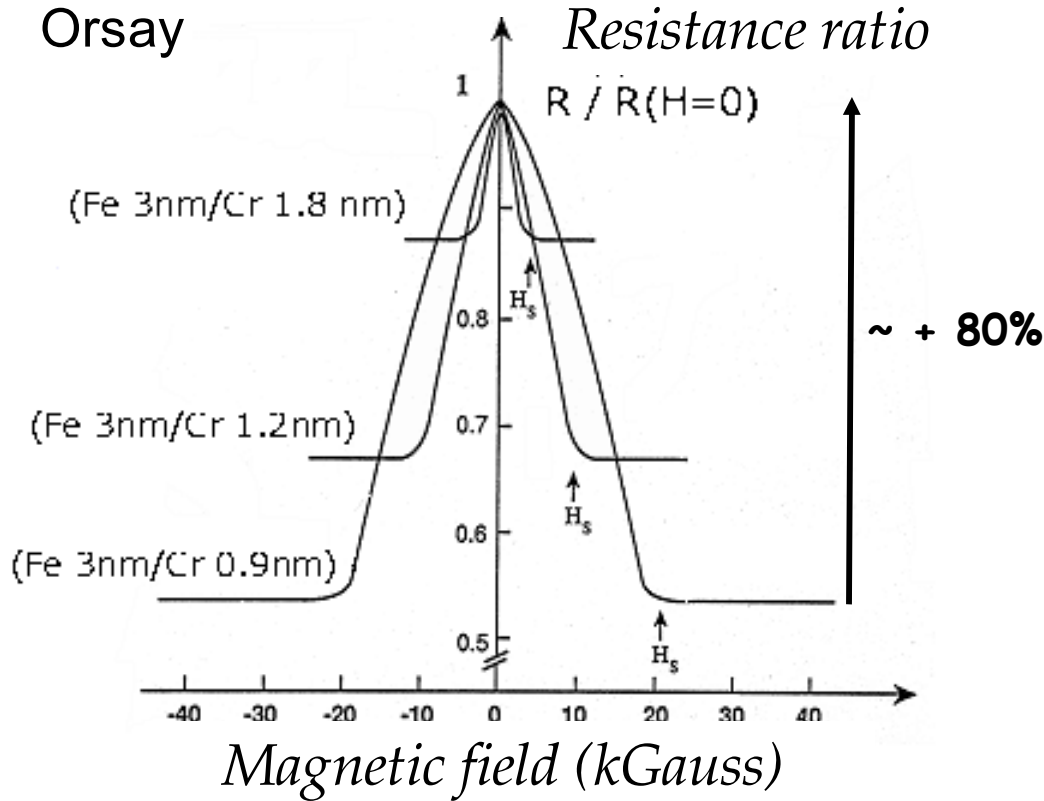


P. Grünberg, 1986 → antiferromagnetic interlayer coupling

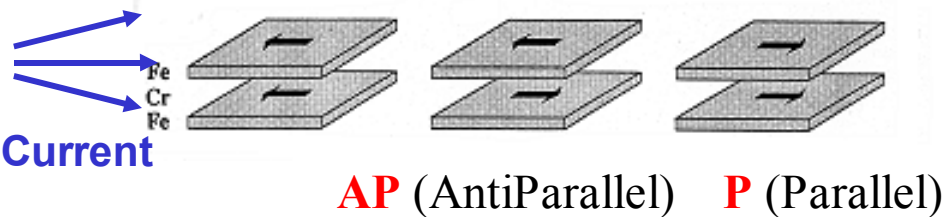
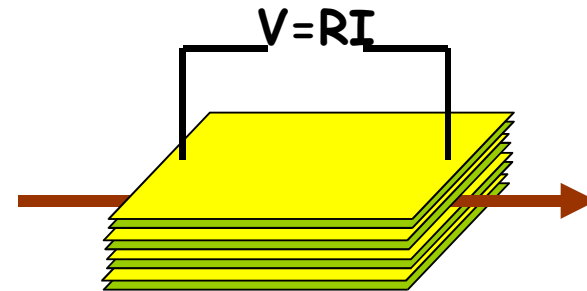
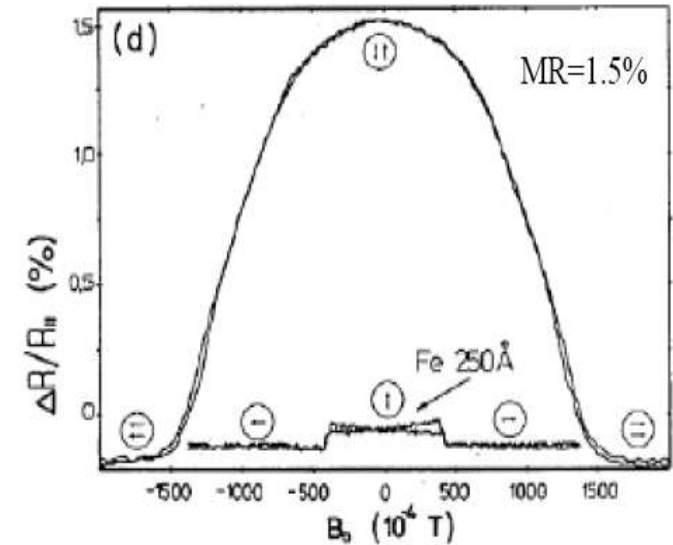
• Giant Magnetoresistance (GMR)

(Orsay, 1988, Fe/Cr multilayers, Jülich, 1989, Fe/Cr/Fe trilayers)

Orsay

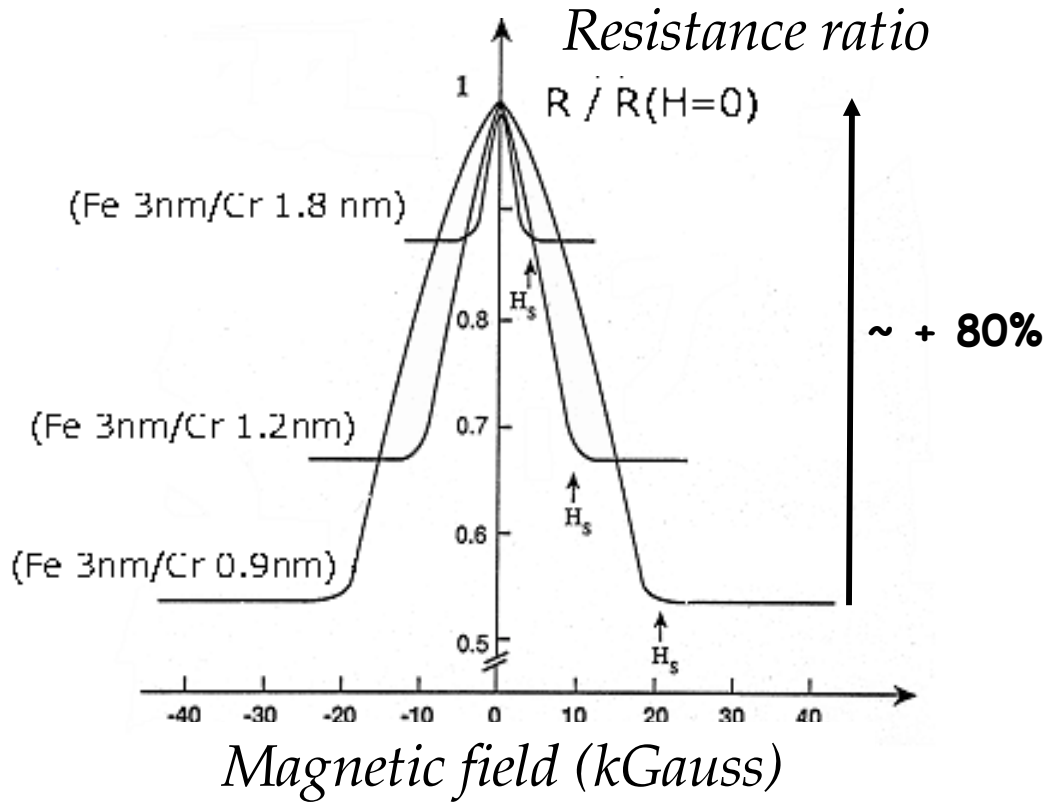


Jülich

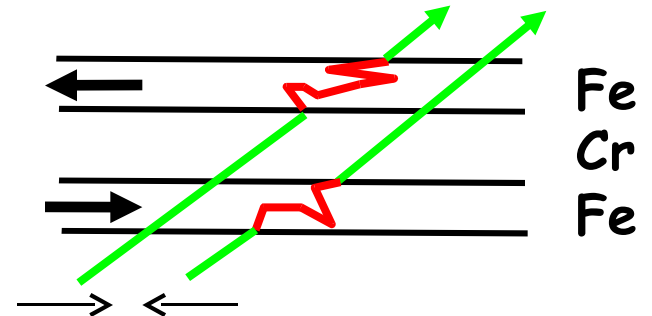


• Giant Magnetoresistance (GMR)

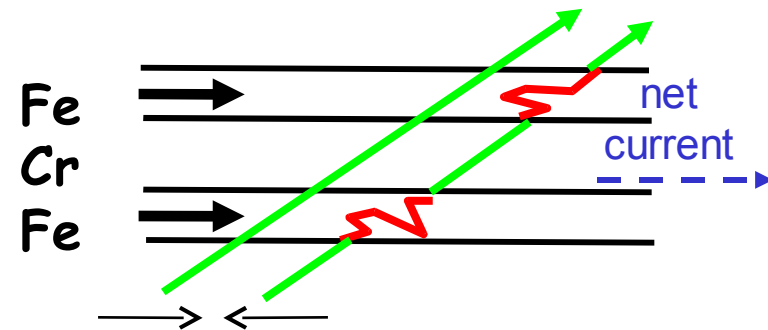
(Orsay, 1988, Fe/Cr multilayers, Jülich, 1989, Fe/Cr/Fe trilayers)



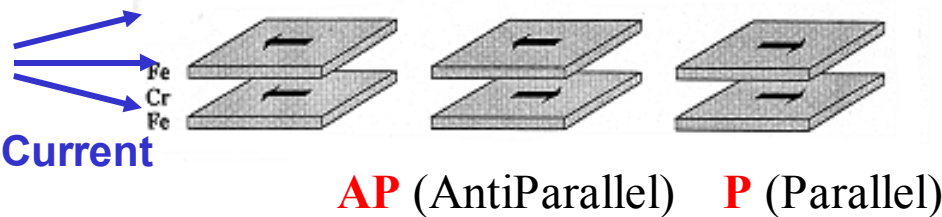
Anti-parallel magnetizations
(zero field, **high** resistance)

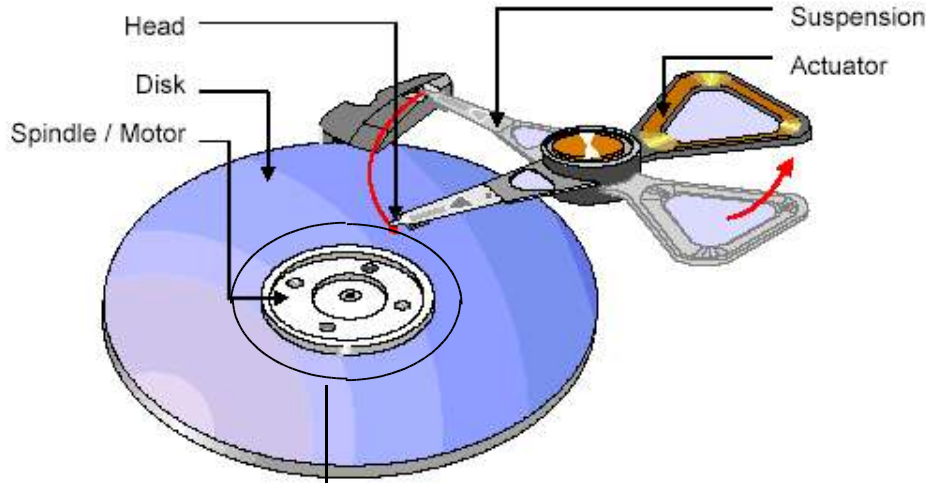


Parallel magnetizations
(appl. field, **low** resist.)

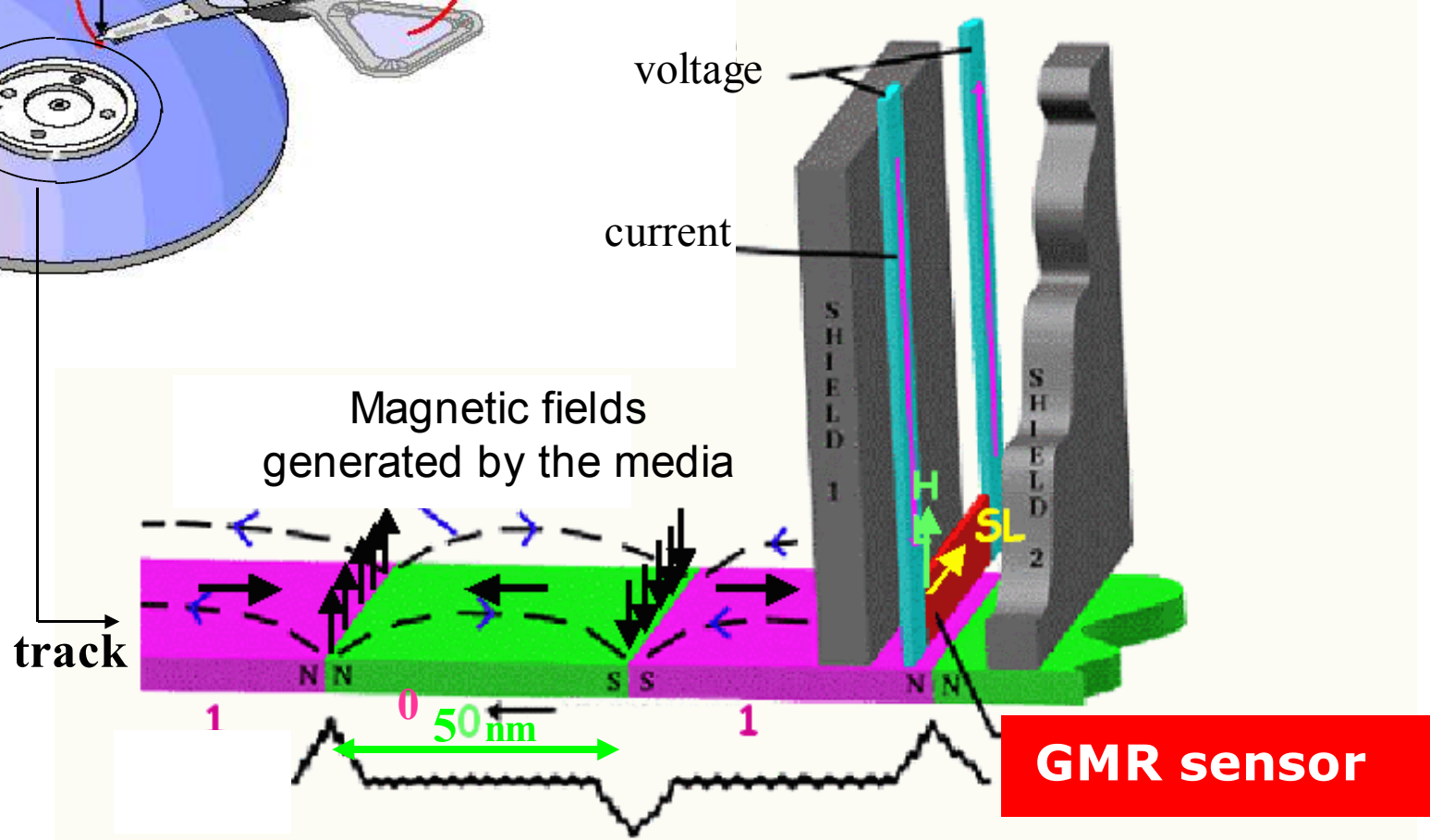


Condition for GMR:
layer thickness \approx nm



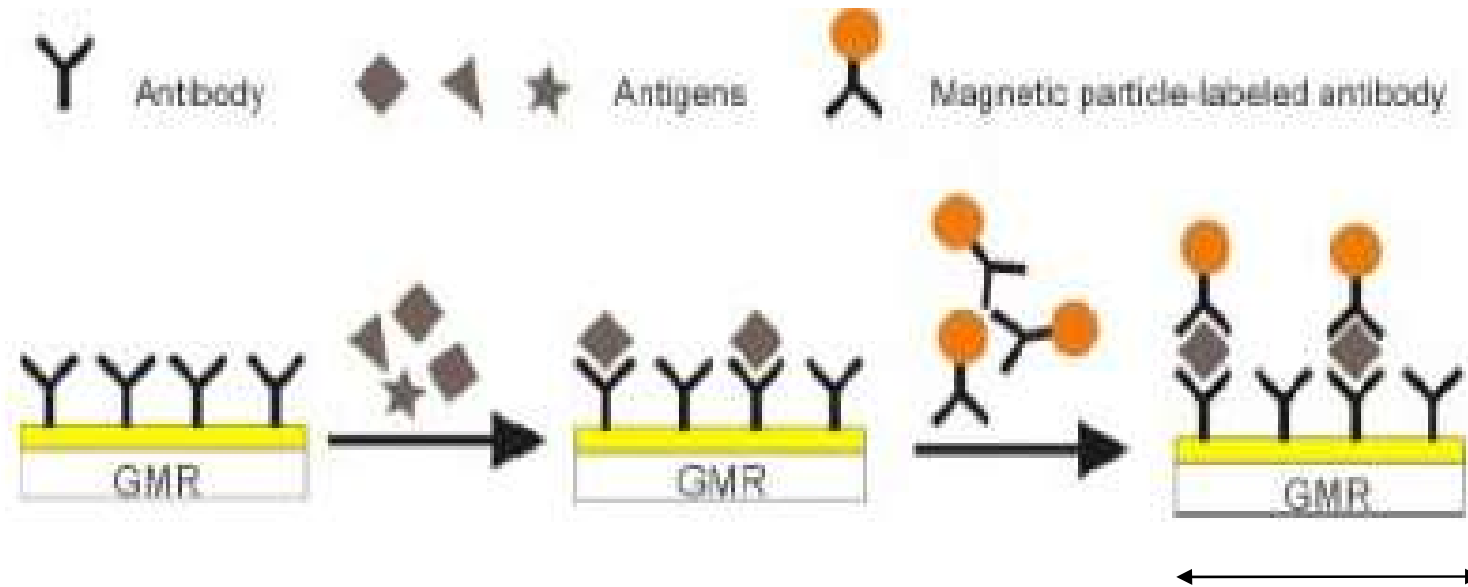


Read head of hard disc drive



1997 (before GMR) : 1 Gbit/in² , 2007 : GMR heads ~ 300 Gbit/in²

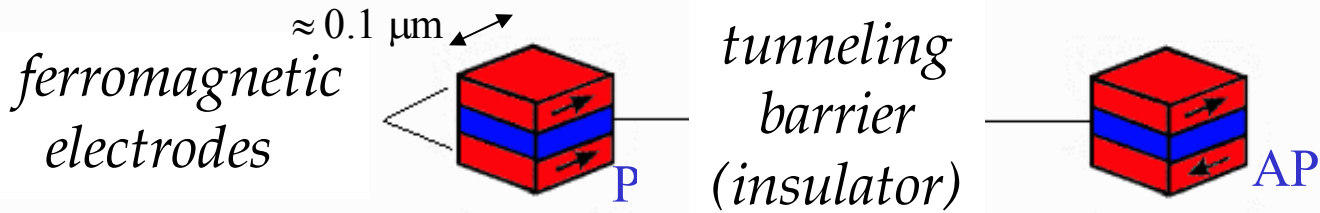
Arrays of GMR biochips for analysis of biomolecules (example: antigens are trapped by antibodies and also decorated by other antibodies labelled by magnetic nanoparticles which are detected by a GMR sensor)



9 μm (Philips), 1 μm (Santa Barbara)

→ Probe arrays for analysis of thousands of different targets in parallel

• Magnetic Tunnel Junctions, Tunneling Magnetoresistance



Jullière, 1975,
low T, hardly
reproducible

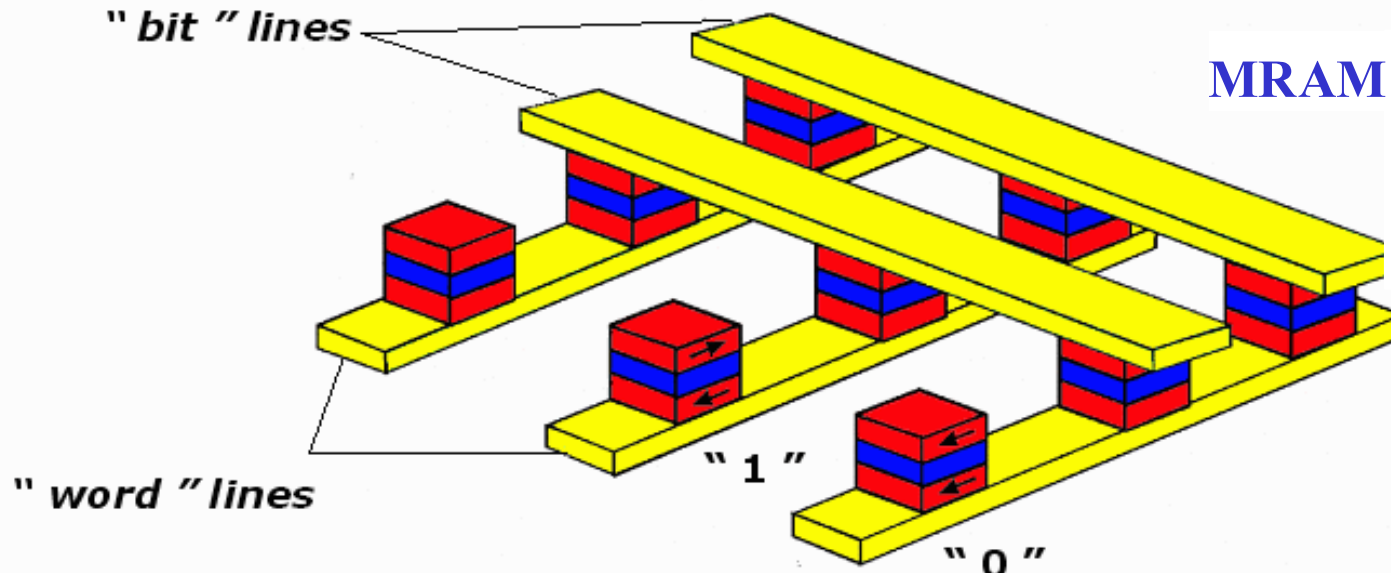
Low resistance state

High resistance state

Moodera et al, 1995, Miyasaki et al, 1995, CoFe/Al₂O₃/Co, MR \approx 30-40%

Applications: - read heads of Hard Disc Drive

- M-RAM (Magnetic Random Access Memory)



MRAM : density/speed of
DRAM/SRAM +
nonvolatility + low
energy consumption

Epitaxial magnetic tunnel junctions (MgO, etc)

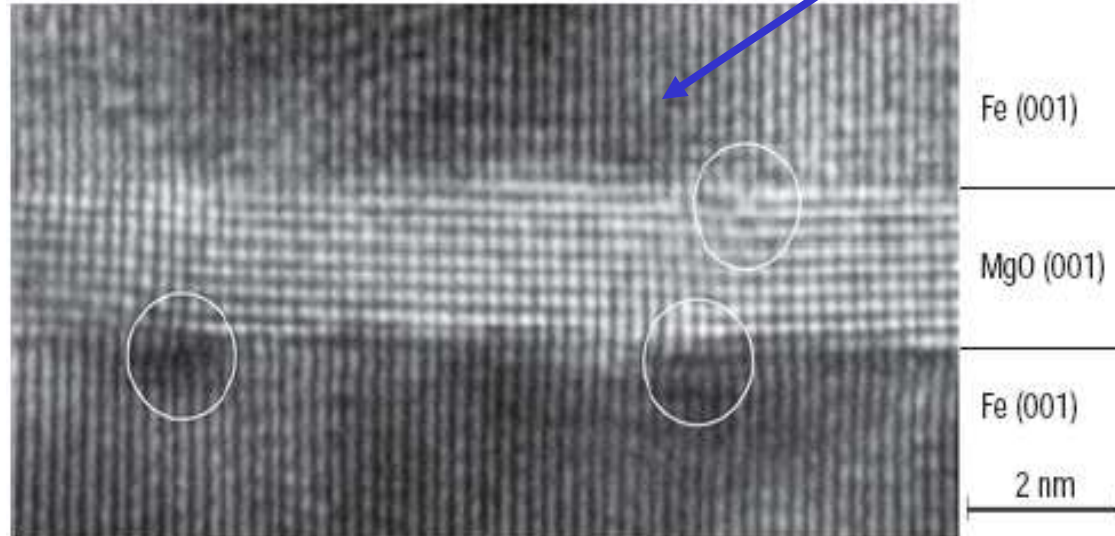
First examples on Fe/MgO/Fe(001):

CNRS/Thales (Bowen, AF et al, APL2001) Nancy (Faure-Vincent et al, APL 2003) Tsukuba (Yuasa et al, Nature Mat. 2005) IBM (Parkin et al, Nature Mat. 2005)etc

Yuasa et al, Fe/MgO/Fe

Nature Mat. 2005

$$\Delta R/R = (R_{AP} - R_P) / R_P \approx 200\% \text{ at RT}$$



**2006-
2007**

CoFeB/MgO/CoFeB,

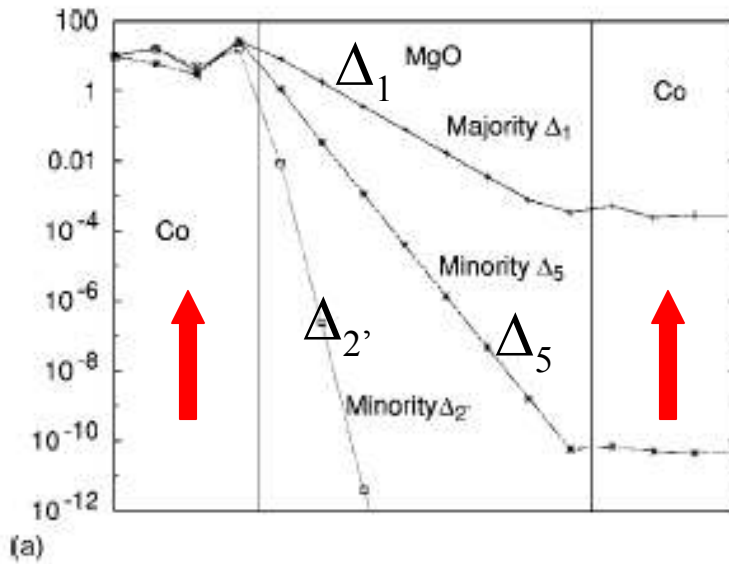
$\Delta R/R \approx 500\%$ at RT in several laboratories in 2006-2007

+

**Clearer picture of the physics of TMR:
what is inside the word
« spin polarization »?**

Mathon and Umerski, PR B 1999
Mavropoulos et al, PRL 2000 Butler
et al , PR B 2001
Zhang and Butler, PR B 2004 [bcc
 Co/MgO/bcc Co(001)]

P



AP

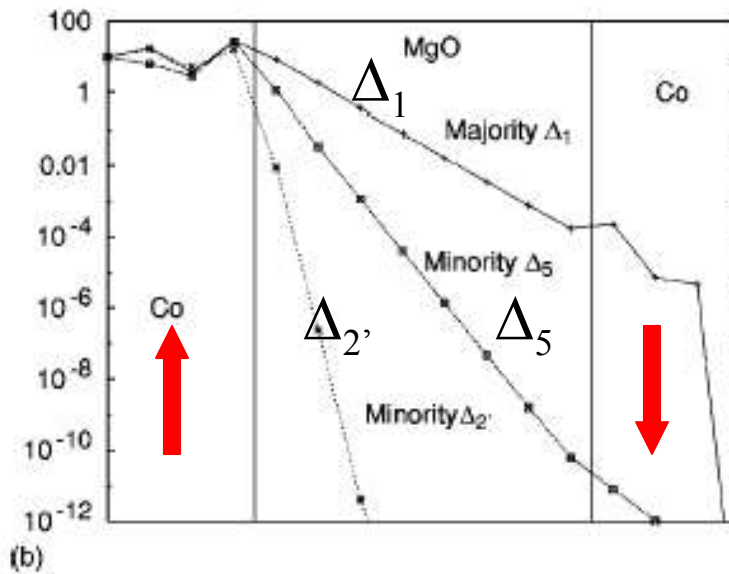


FIG. 2. Tunneling density of states on each atomic layer at $k_{\parallel}=0$ for the Co/MgO/Co tunnel junction. Top panel: parallel spin alignment, bottom panel: antiparallel spin alignment

MgO, ZnSe (Mavropoulos et al, PRL 2000), etc

→ Δ_1 symmetry (sp) slowly decaying

→ tunneling of Co **majority** spin electrons

SrTiO₃ and other **d-bonded insulators**

(Velev et al, PRL 95, 2005; Bowen et al, PR B 2006)

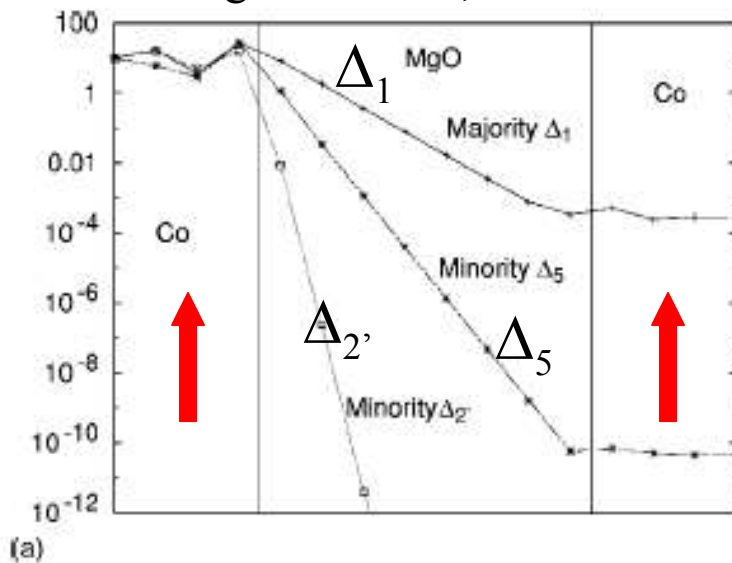
→ Δ_5 symmetry (d) slowly decaying

→ tunneling of **Co minority** spin electrons

in agreement with the **negative polarization of Co** found in TMR with **SrTiO₃, TiO₂** and **Ce_{1-x}La_xO₂** barriers

(de Teresa, A.F. et al, Science 1999)

P



AP

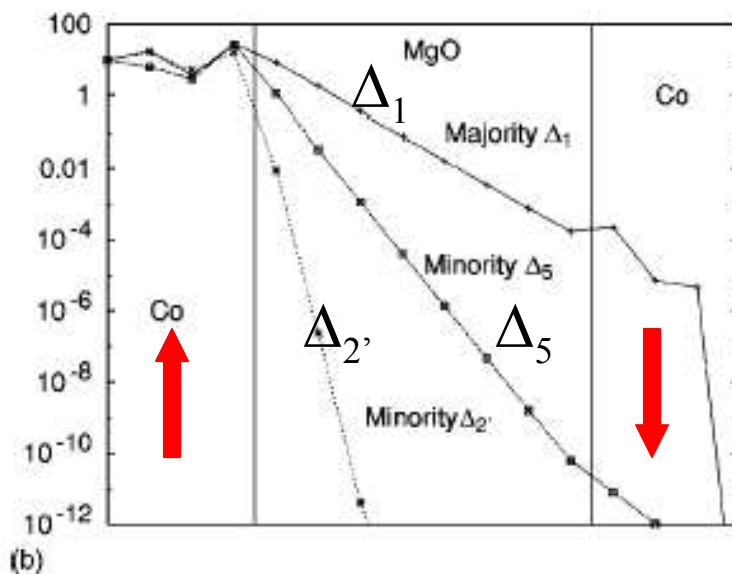


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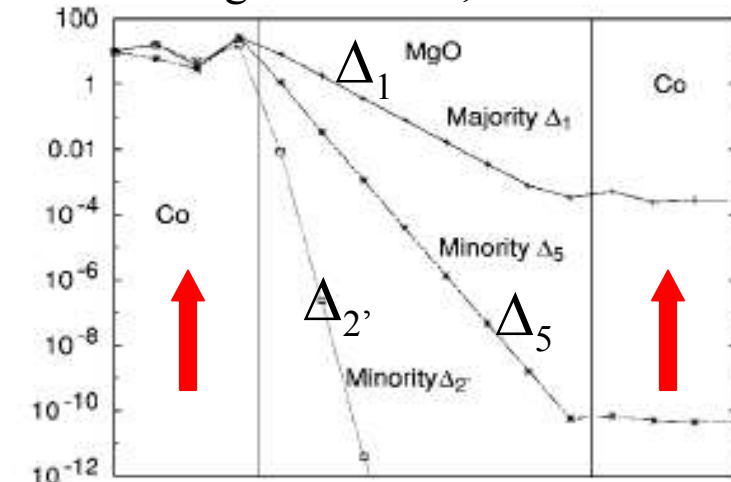
→ Δ_5 symmetry (d) slowly decaying

→ tunneling of Co minority spin electrons

in agreement with the physical basis of « spin negative polarization of Co found in TMR with SrTiO₃, TiO₂ and Ce_{1-x}La_xO₂ barriers »
 « Tunneling: SP of the DOS for the symmetry selected by the barrier »
 (de Teresa, A.F. et al, Science 1999)

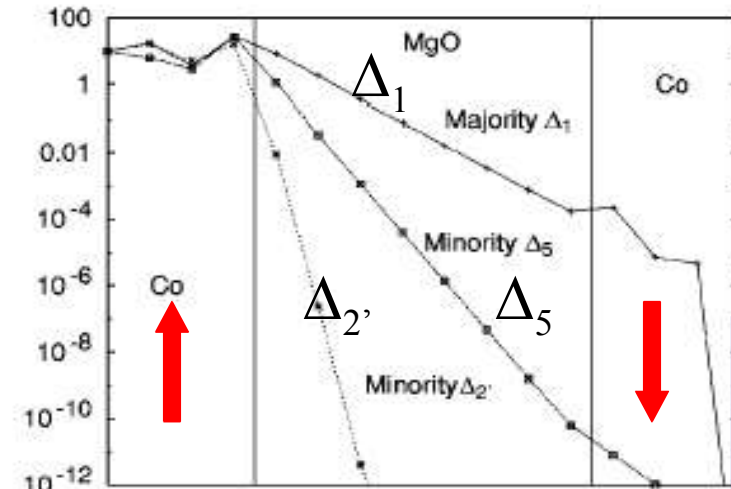
« Electrical conduction: SP depends on scatterers, impurities,...

P



(a)

AP



(b)

FIG. 2. Tunneling density of states on each atomic layer at k_{\parallel} = 0 for the Co/MgO/Co tunnel junction. Top panel: parallel spin alignment, bottom panel: antiparallel spin alignment

Spin Transfer

(magnetic switching, microwave generation)

Spintronics with semiconductors

Spintronics with molecules

Spin Transfer

(magnetic switching, microwave generation)

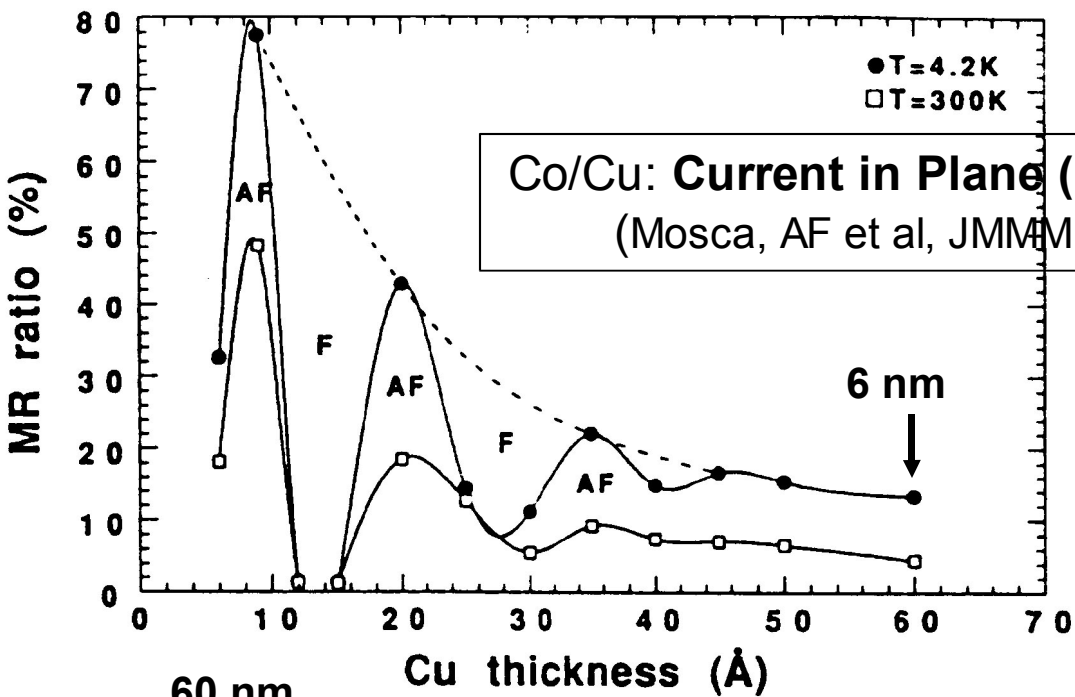
Spintronics with semiconductors

Spintronics with molecules

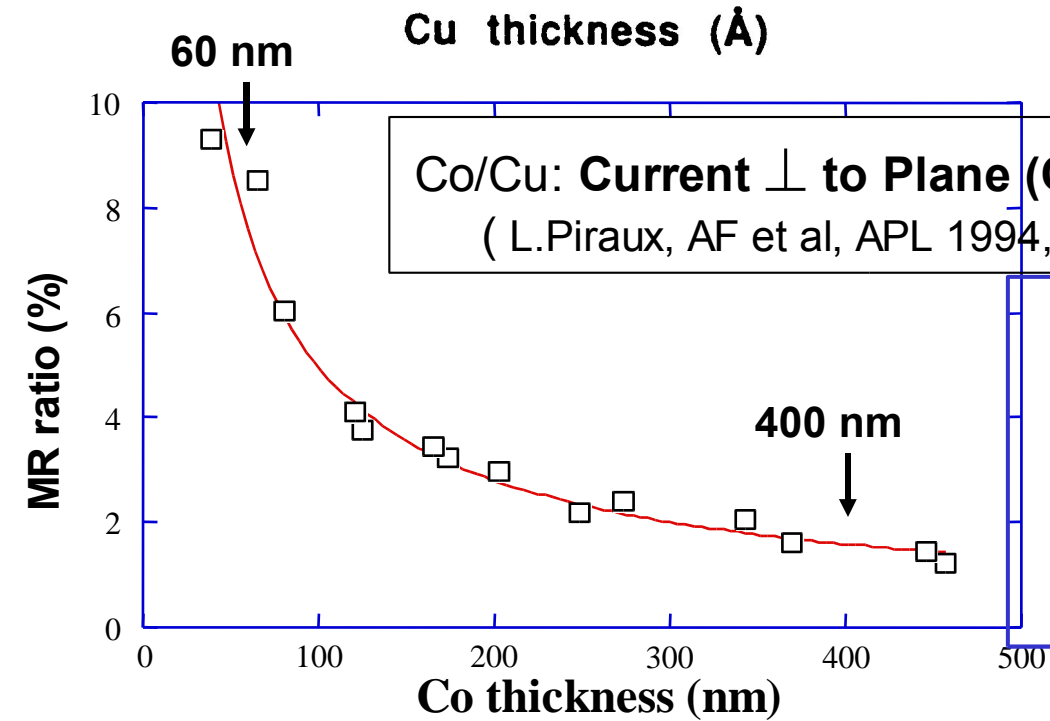
Introduction:

spin accumulation

and spin currents

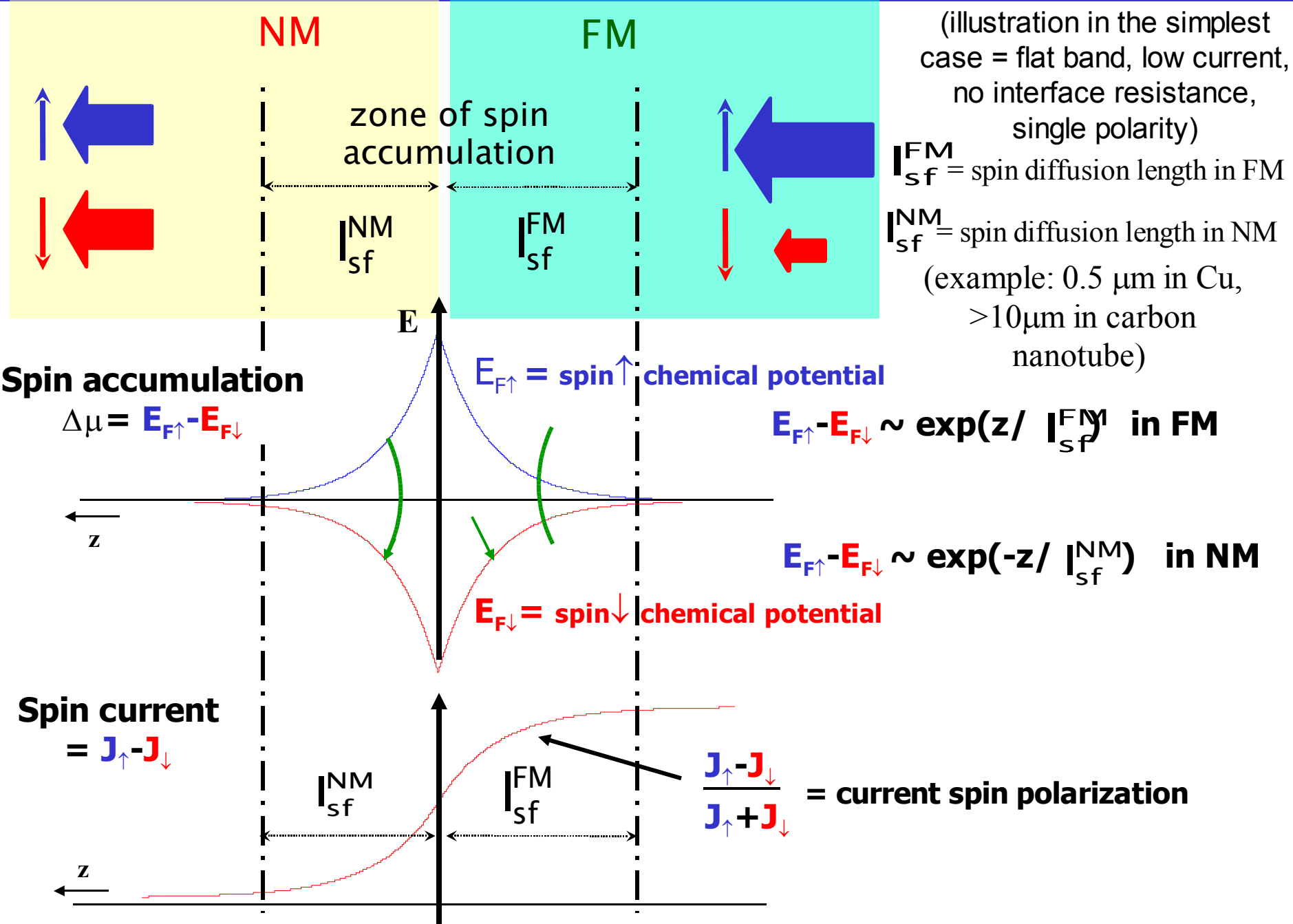


CIP-GMR
scaling length = mean free path

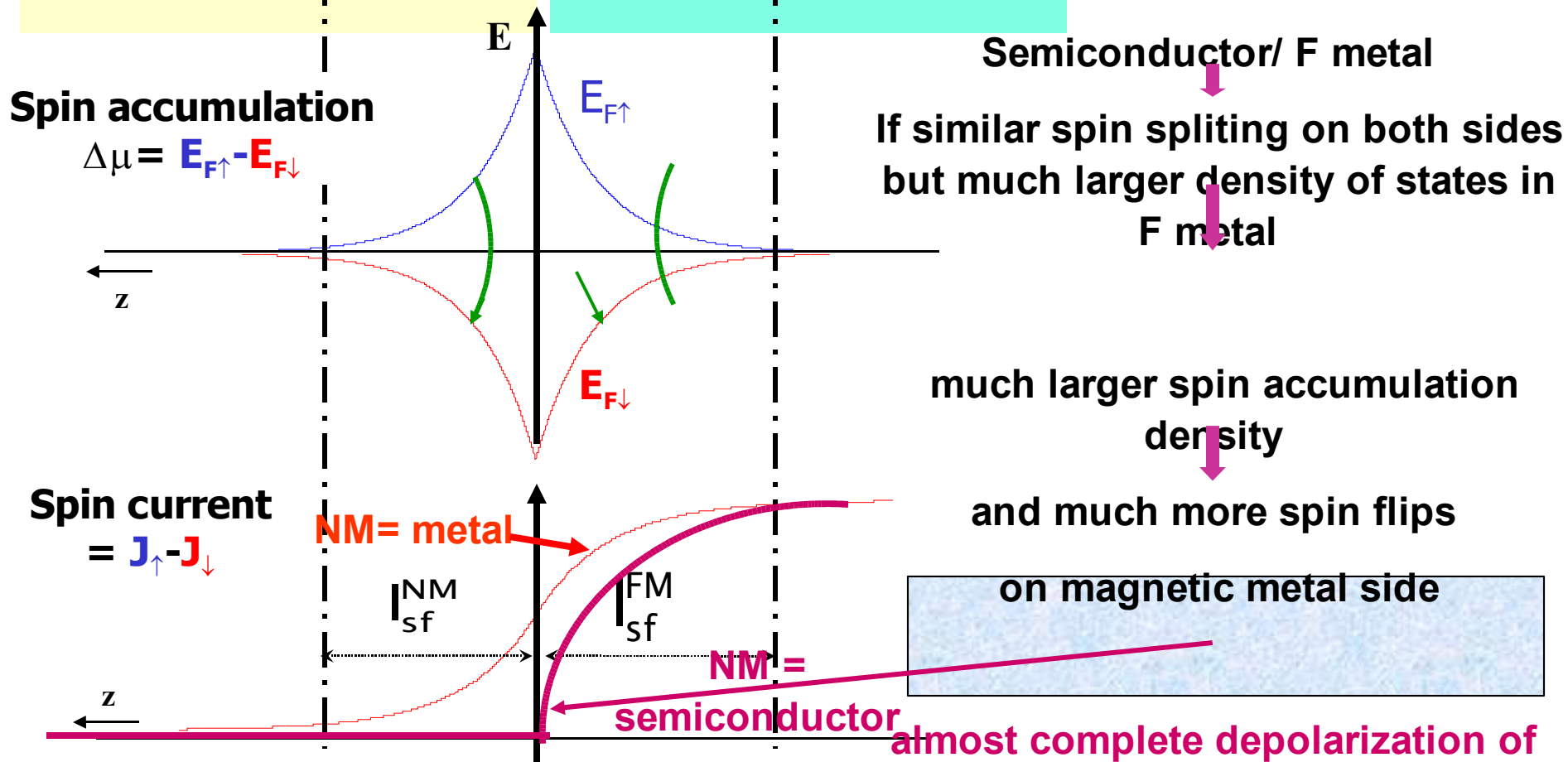
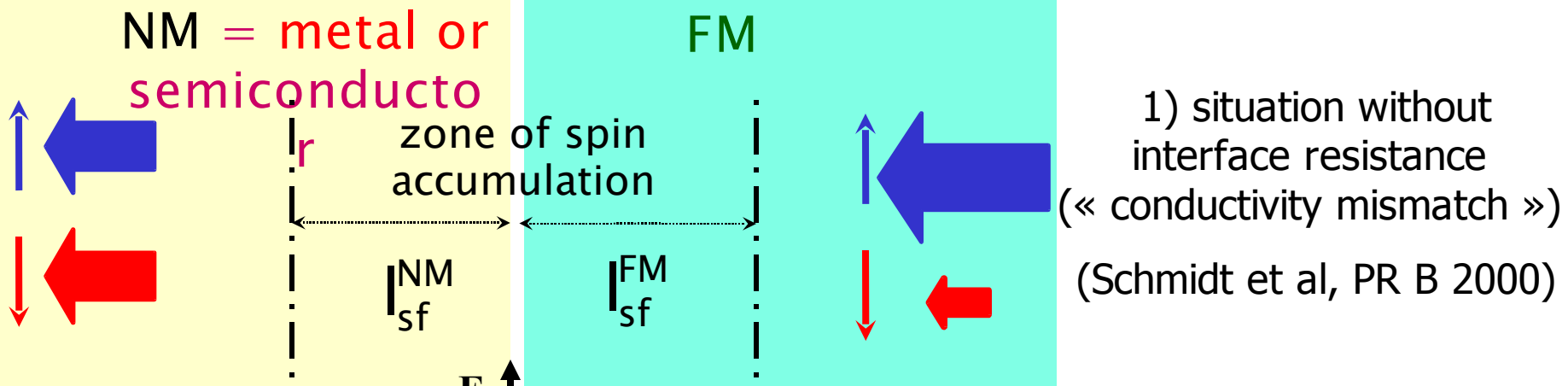


CPP-GMR
scaling length = spin diffusion length \gg mean free path
spin accumulation theory,
(Valet-Fert, PR B 1993)

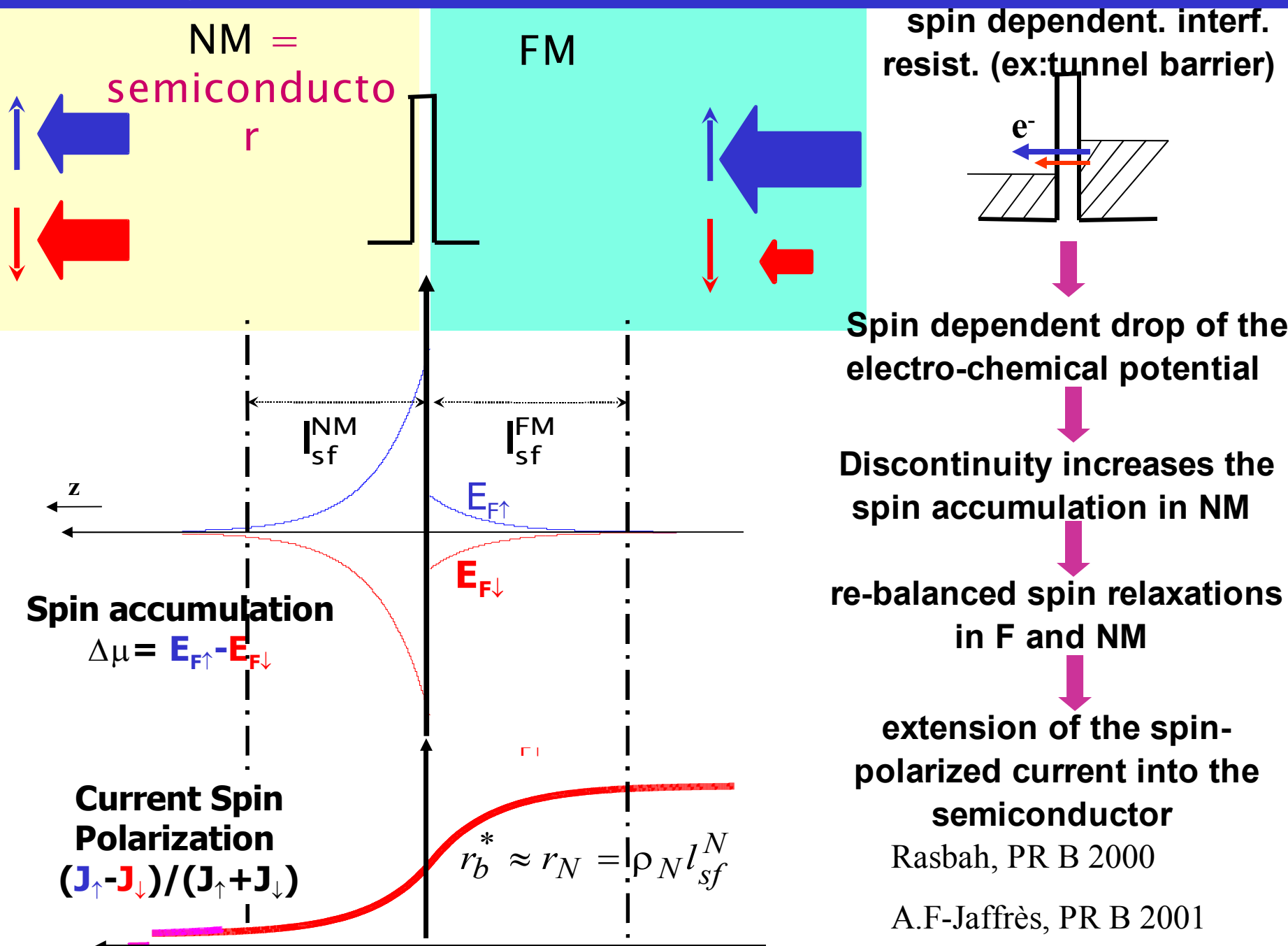
Spin injection/extraction at a NM/FM interface (beyond ballistic range)



Spin injection/extraction at a Semiconductor/FM interface

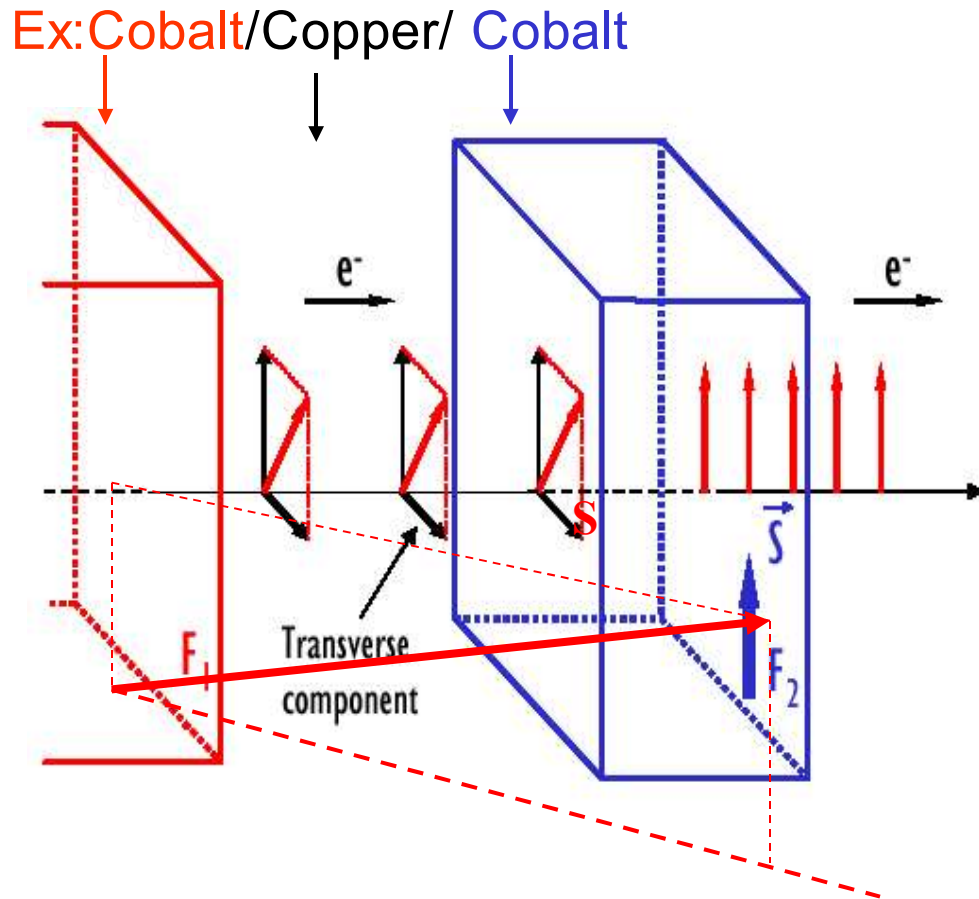


Spin injection/extraction at a Semiconductor/FM interface



Spin transfer

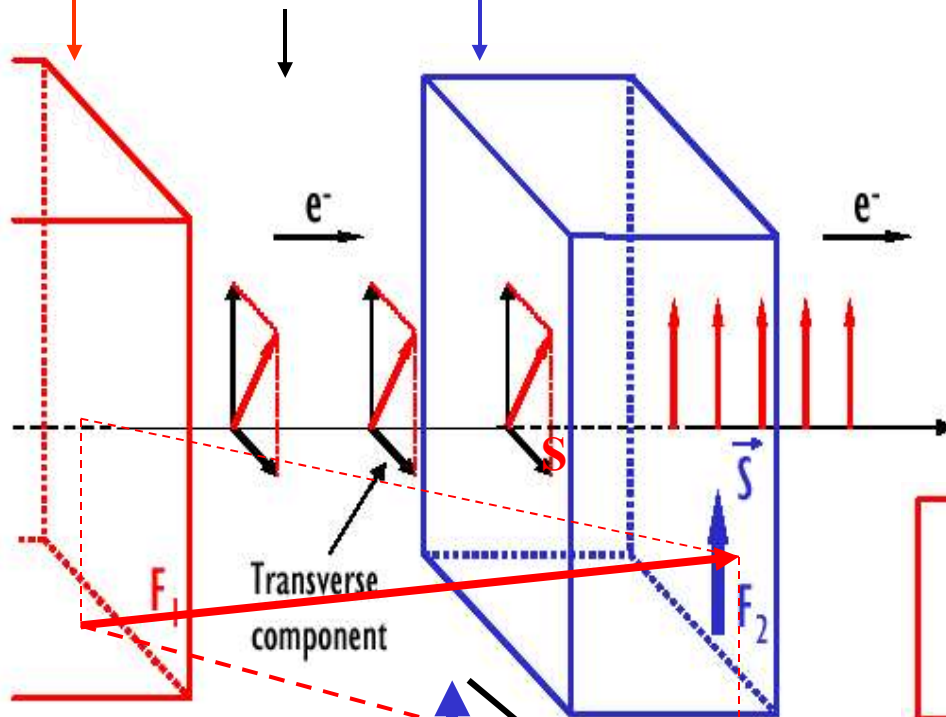
(J. Slonczewski, JMMM 1996, L. Berger, PR B 1996)



Spin transfer

(J. Slonczewski, JMMM 1996, L. Berger, PR B 1996)

Ex: Cobalt/Copper/ Cobalt

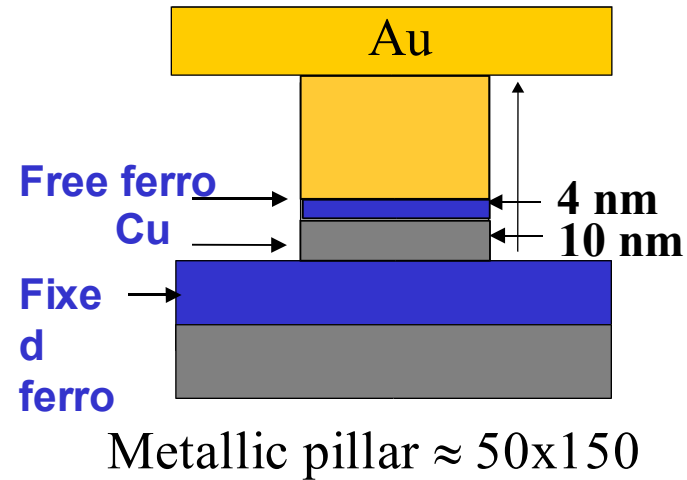


The transverse component of the spin current is absorbed and transferred to the total spin of the layer

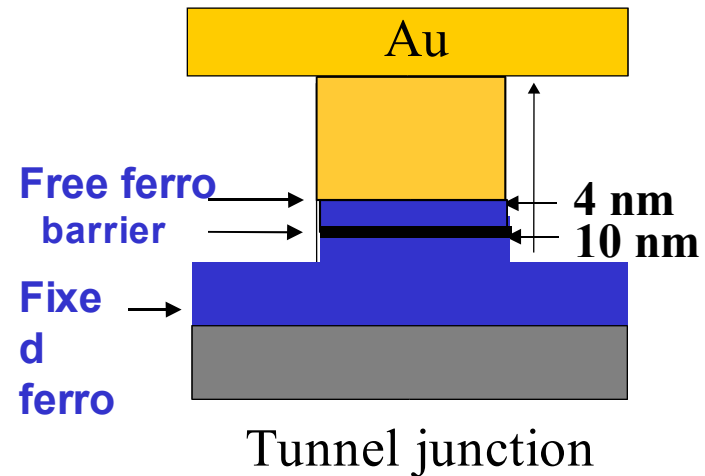
$$\frac{\text{torque}}{\hbar} = \left(\frac{d\vec{S}}{dt} \right)_i = \text{absorbed transverse spin current} \propto j \mathbf{M} \times (\mathbf{M} \times \mathbf{M}_0)$$

≡ Torque on \mathbf{S}
 $\approx \mathbf{M} \times (\mathbf{M} \times \mathbf{M}_0)$

Experiments on pillars



nm²



E-beam lithography + etching

a) **First regime (low H):**
irreversible switching
(CIMS)

b) **Second regime (high H):**
steady precession
(microwave generation)

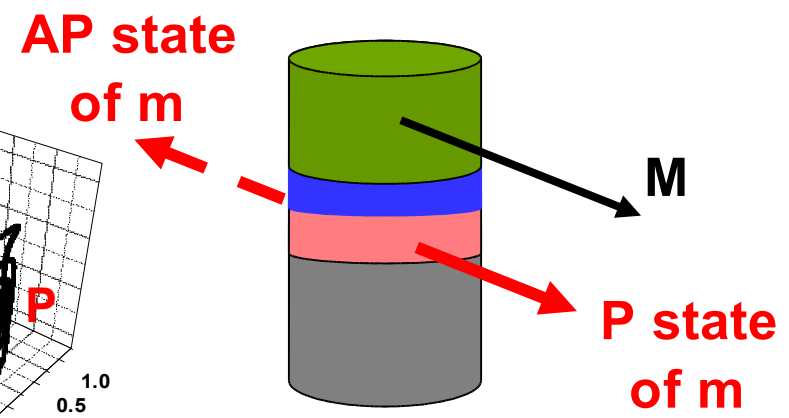
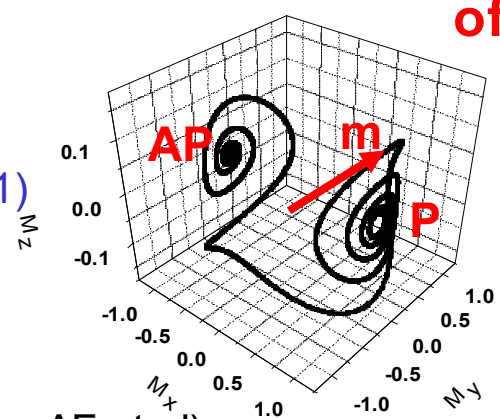
Regime of irreversible magnetic switching

First experiments on pillars:

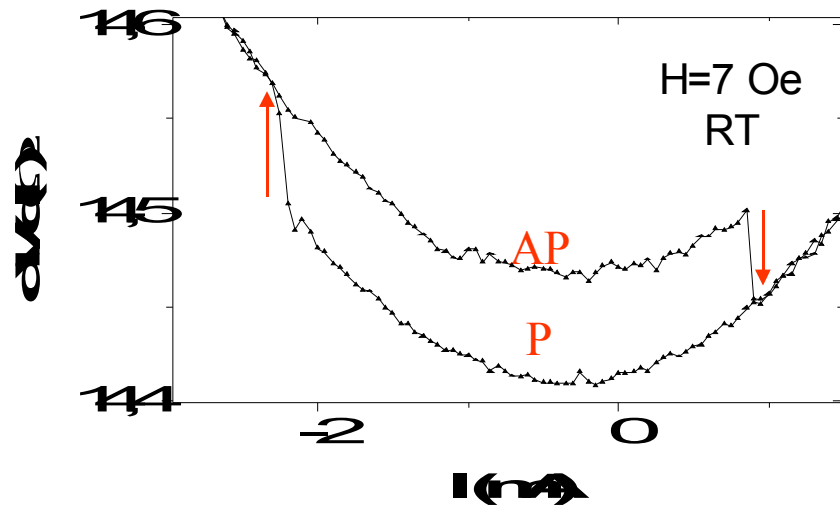
Cornell (Katine et al, PRL 2000)

CNRS/Thales (Grollier et al, APL 2001)

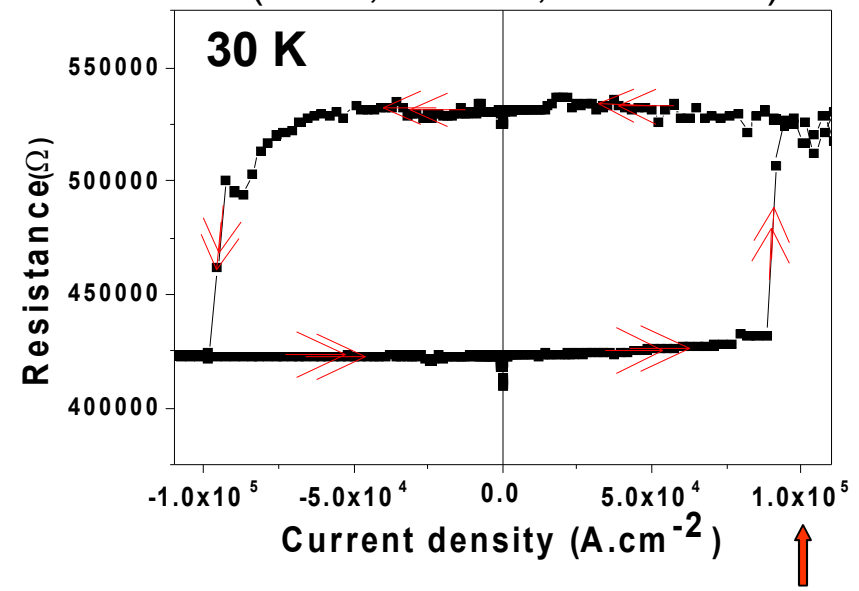
IBM (Sun et al, APL 2002)



Py/Cu/Py 50nmX150nm (Boulle, AF et al)



GaMnAs/InGaAs/GaMnAs tunnel junction (MR=150%)
(Elsen, AF et al, PR B 2006)



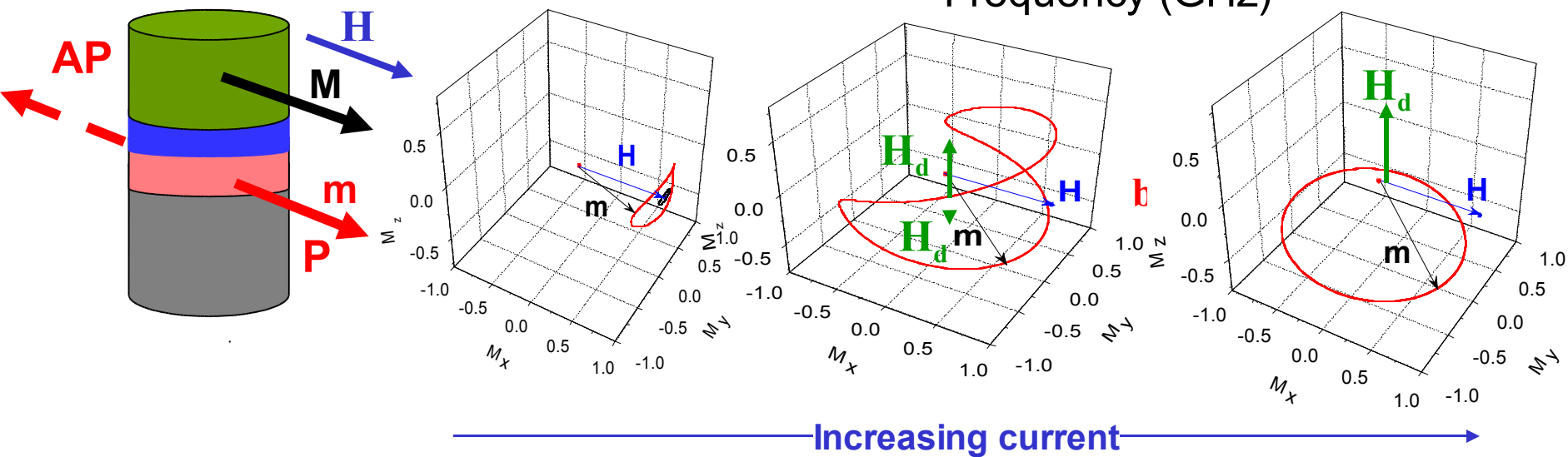
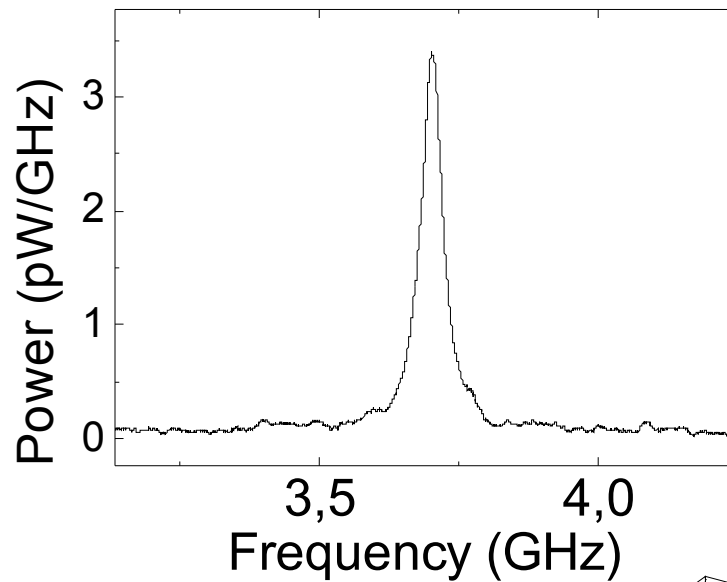
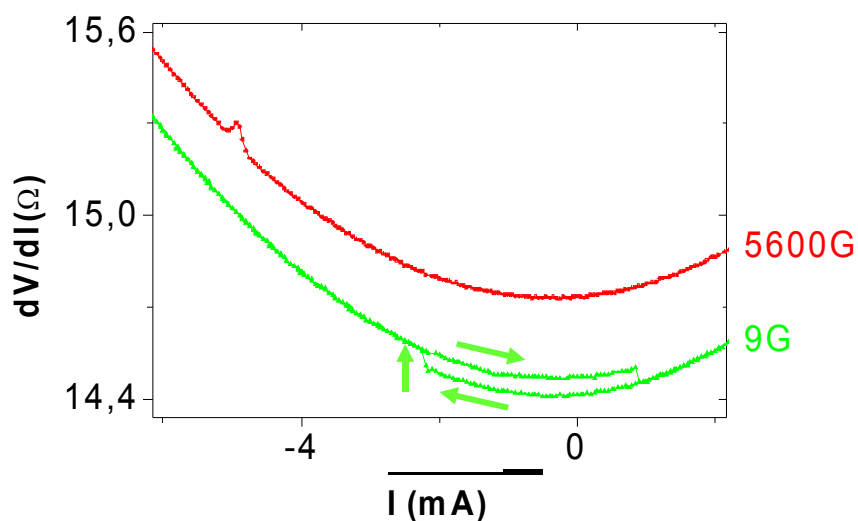
typical switching current $\approx 10^7 A/cm^2$

switching time can be as short as 0.1 ns (Chappert et al)

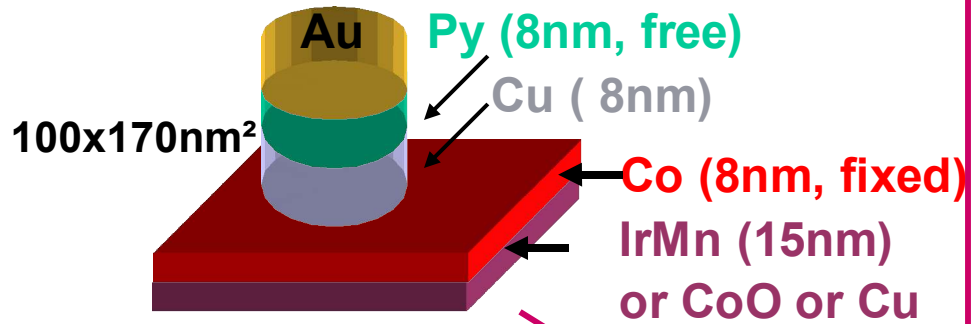
$1 \times 10^5 A/cm^2$

Regime of steady precession (microwave frequency range)

CNRS/Thales, Py/Cu/PY (Grollier et al)
(Py = permalloy)

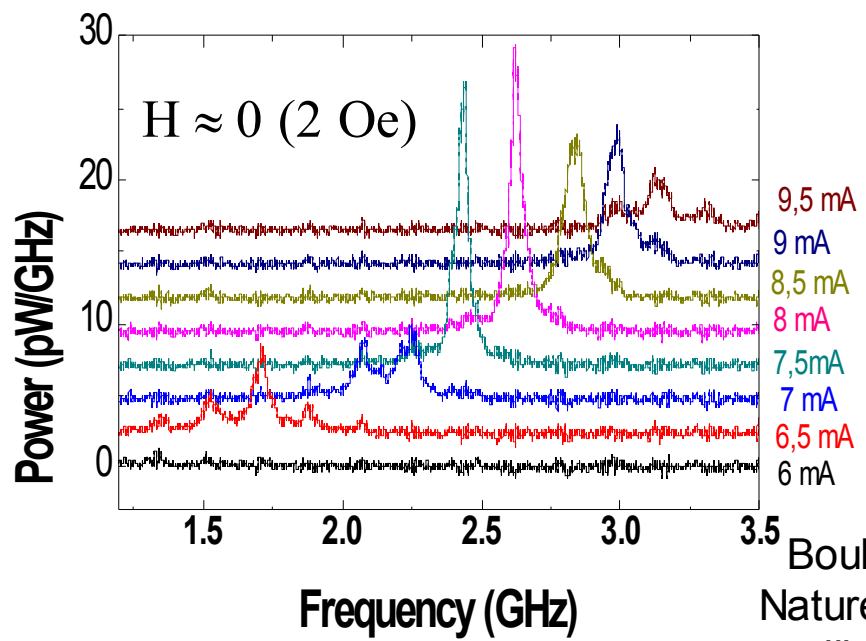
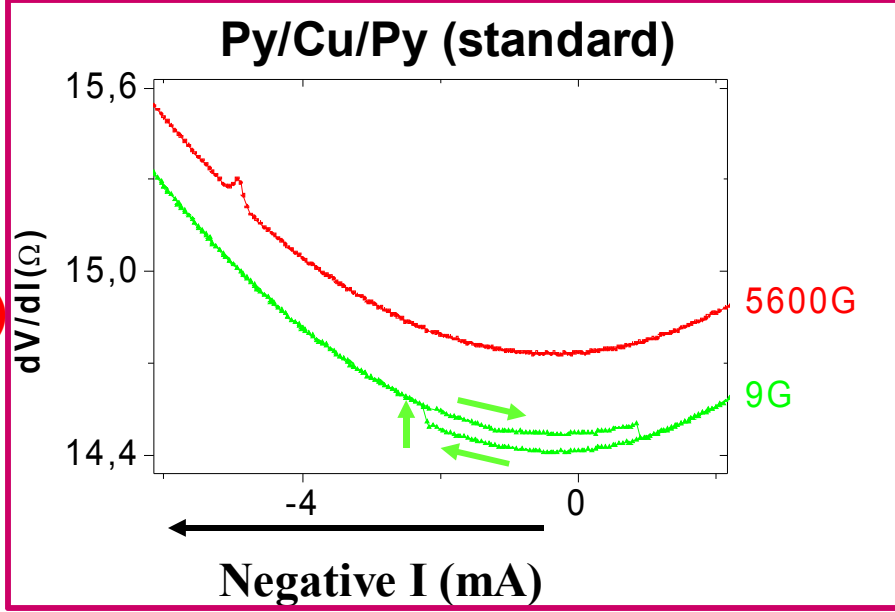


Co/Cu/Py (« wavy » angular variation
calculated by Barnas, AF et al, PR B 2005)

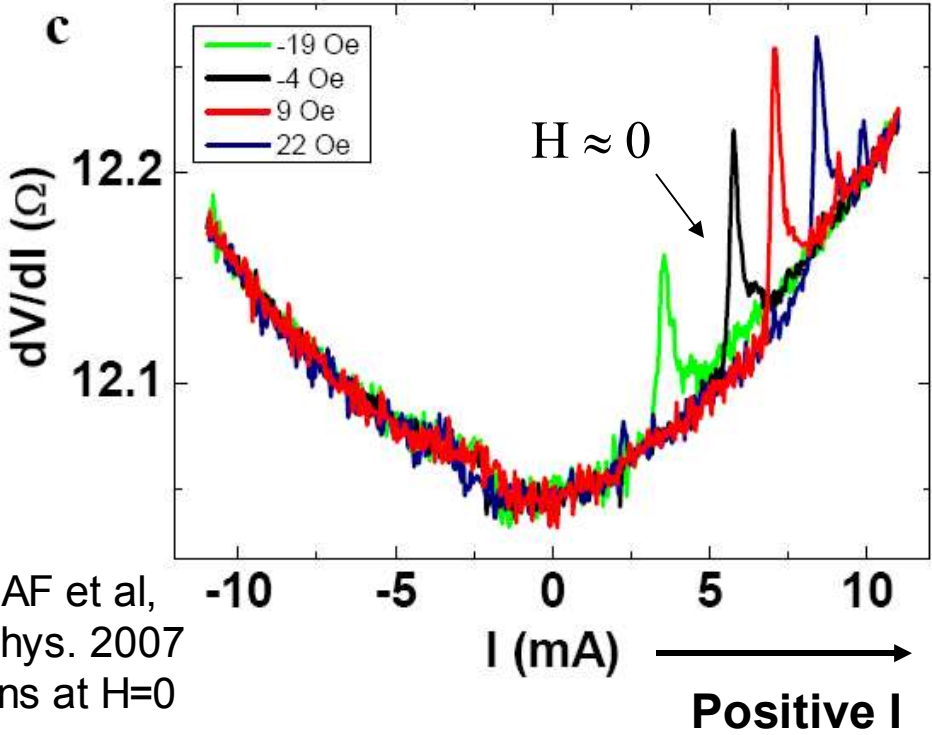


free Py: fast spin
relaxation

fixed Co: slower spin
relaxation



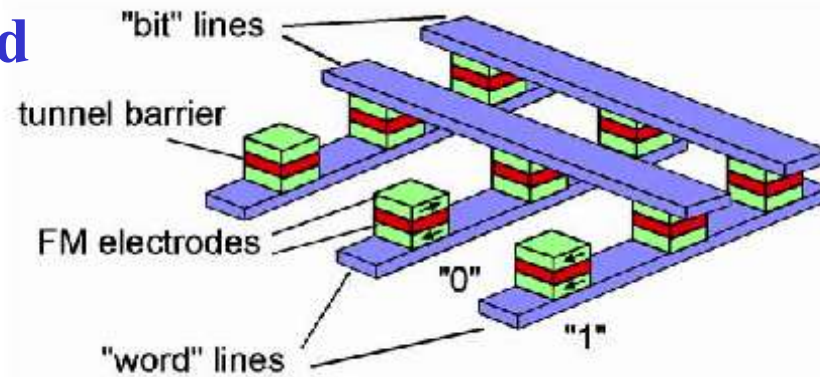
Bouille, AF et al,
Nature Phys. 2007
oscillations at H=0



Switching of reprogrammable devices (example: MRAM)

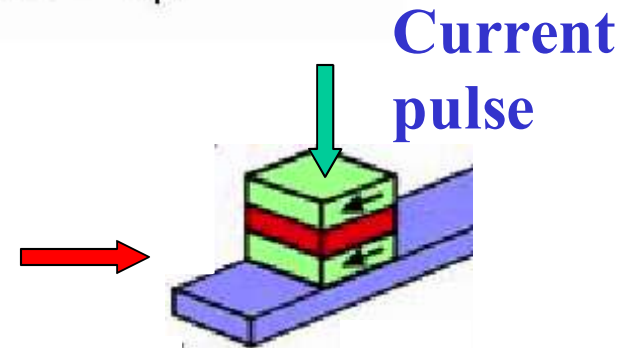
1) By external magnetic field

*(present generation of MRAM,
nonlocal, risk of « cross-talk »
limits integration)*



2) «Electronic» reversal by spin transfer from current

*(for the next generation of MRAM, with already
promising demonstrations by several companies)*



Spin Transfer Oscillators (STO) (communications, microwave pilot)

Advantages:

-direct oscillation in the microwave range (5-40 GHz)

-agility: control of frequency by dc current amplitude, (frequency modulation, fast switching)

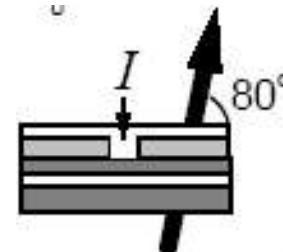
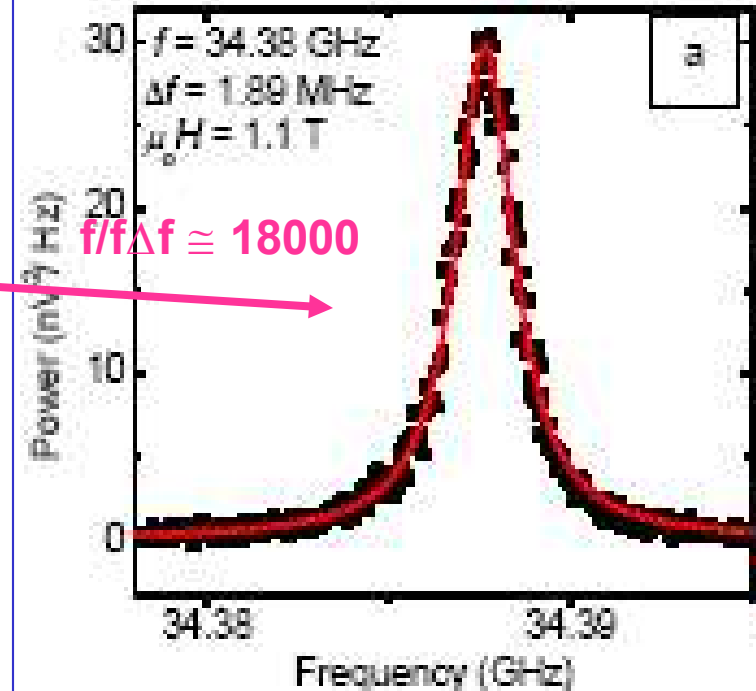
- high quality factor

- small size ($\approx 0.1\mu\text{m}$) (on-chip integration)

-oscillations without applied field

-Needed improvements

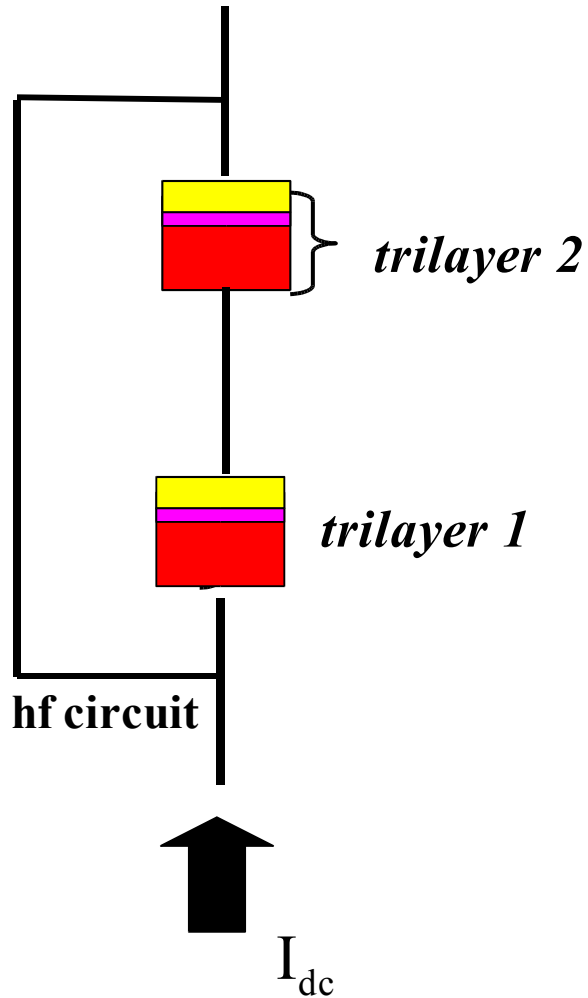
- - increase of power by synchronization of



Rippart et al, PR
B70, 100406,
2004

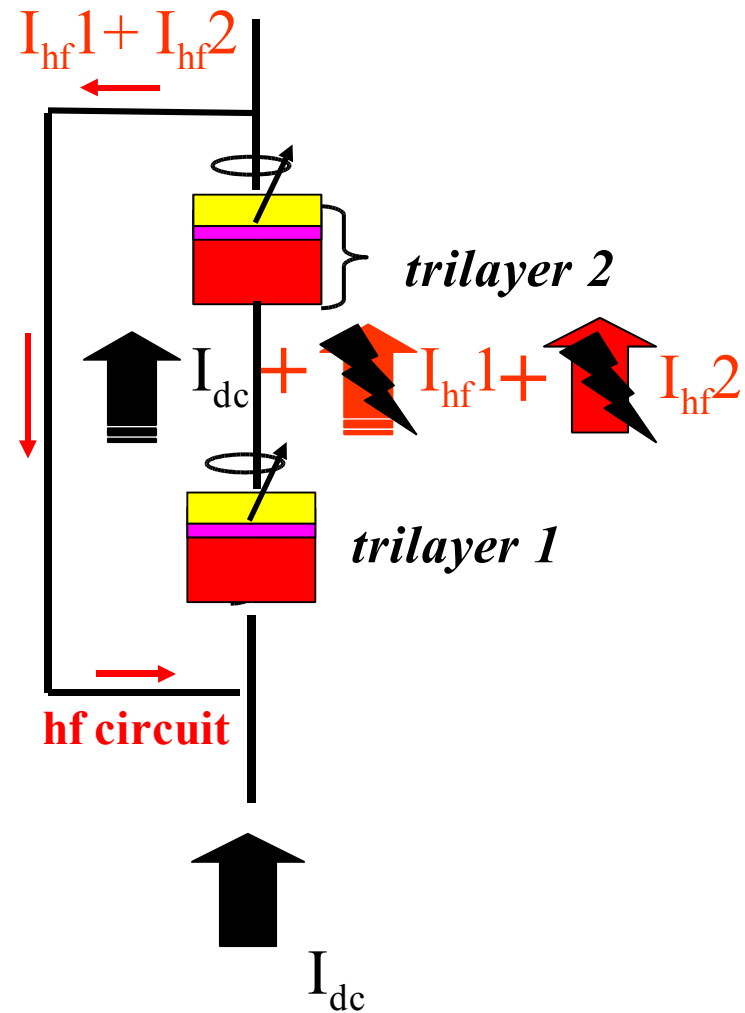
Experiments of STO synchronization by electrical connection

(B.Georges, AF et al, CNRS/Thales and LPN-CNRS, preliminary results)



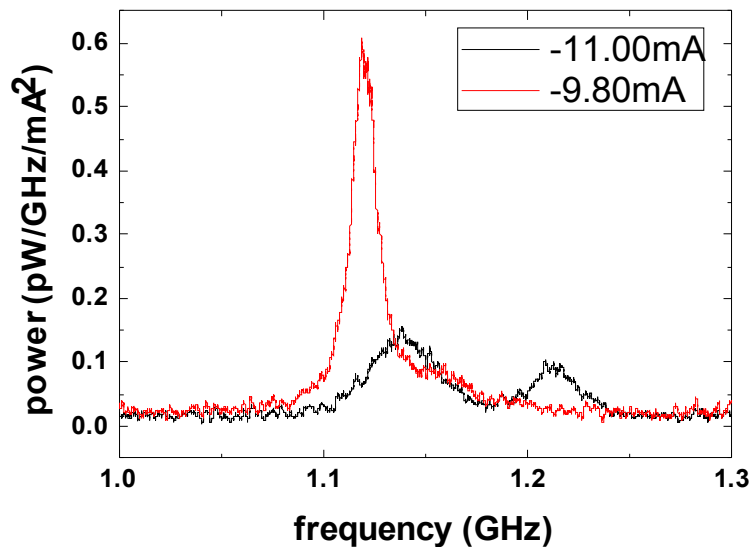
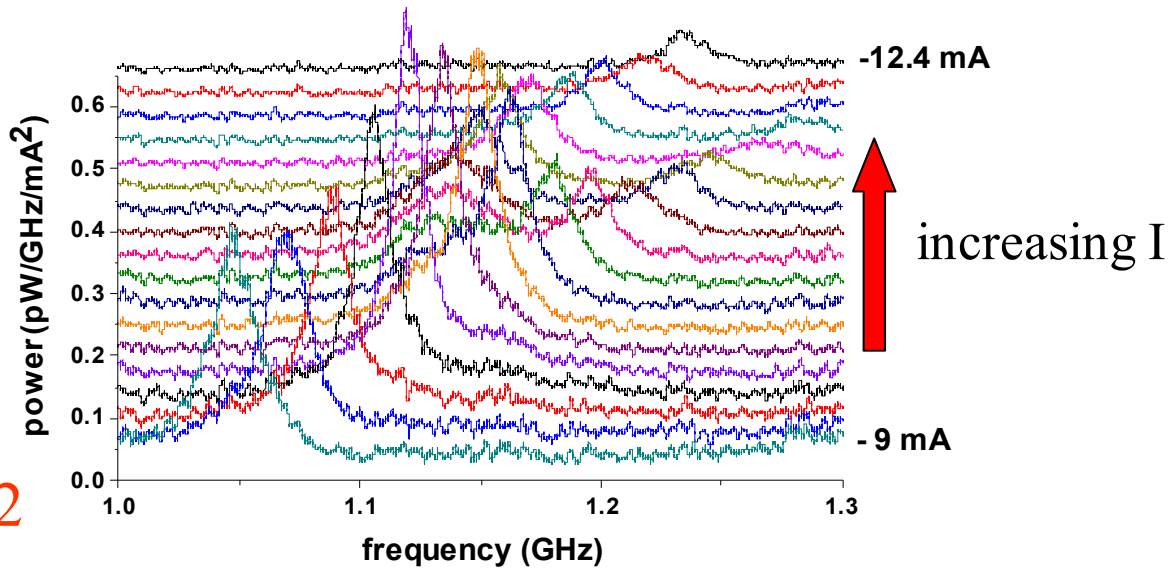
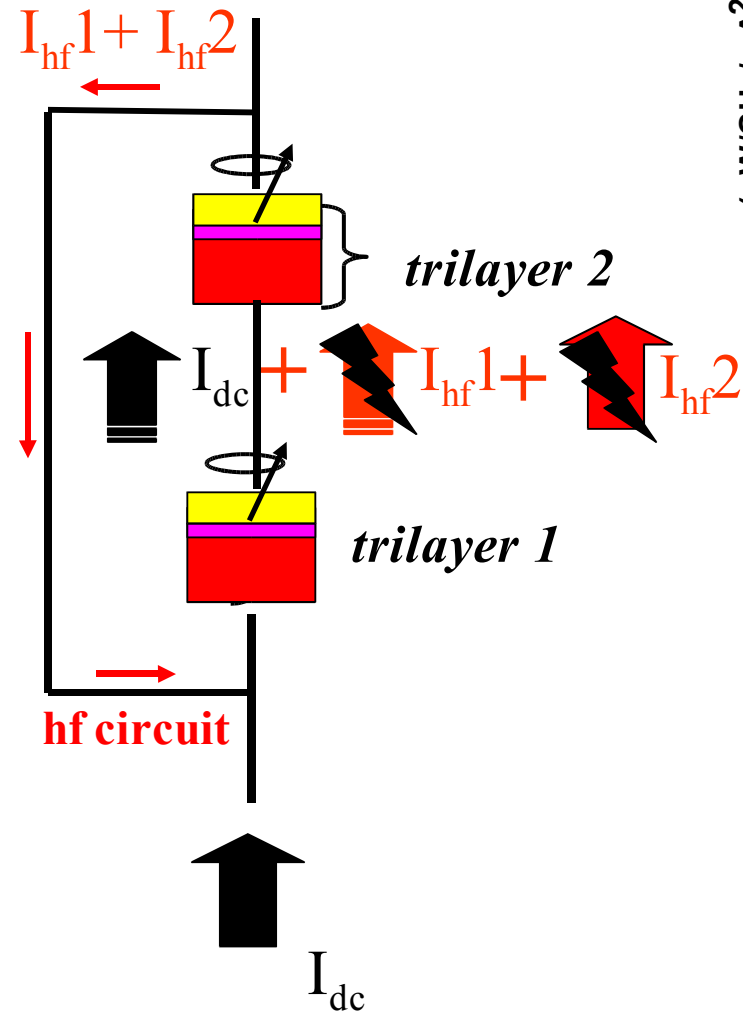
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Experiments of STO synchronization by electrical connection

(B.Georges, AF et al, CNRS/Thales and LPN-CNRS, preliminary results)

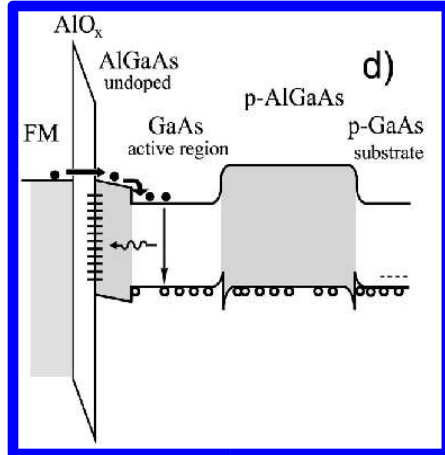


Spintronics with semiconductors and molecules

Spintronics with semiconductors

Magnetic metal/semiconductor hybrid structures

Example: spin injection from Fe into LED
(Mostnyi et al, PR. B 68, 2003)



Ferromagnetic semiconductors (FS)

GaMnAs ($T_c \rightarrow 170\text{K}$) and R.T. FS

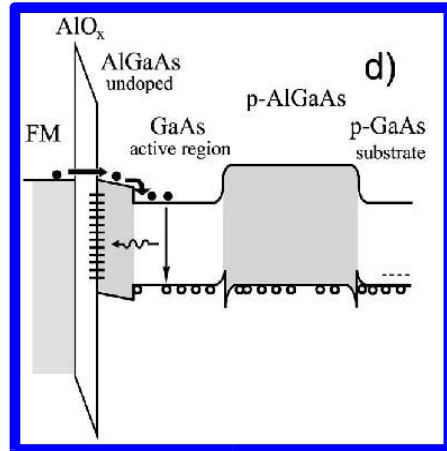
Electrical control of ferromagnetism

TMR, TAMR, spin transfer (GaMnAs)

Field-induced metal/insulator transition

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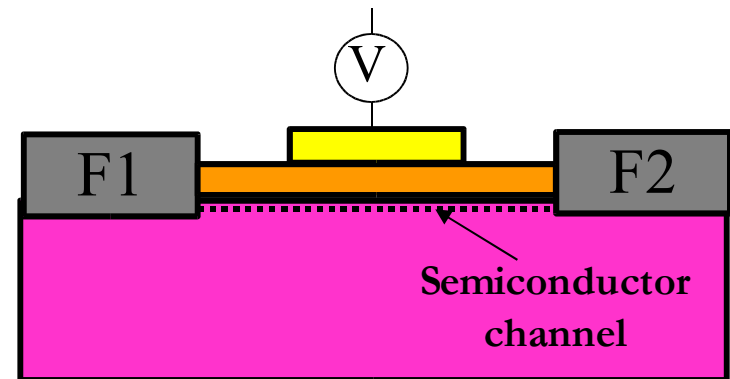
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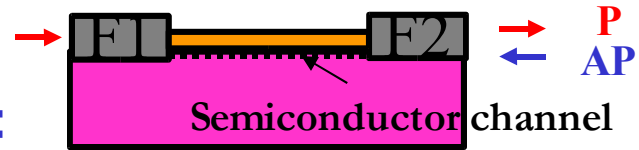
Field-induced metal/insulator transition

Spin Field Effect Transistor ?



Semiconductor channel between spin-polarized source and drain transforming spin information into large (?) and tunable (by gate voltage) electrical signal

Nonmagnetic lateral channel between spin-polarized source and drain



Semiconductor channel:

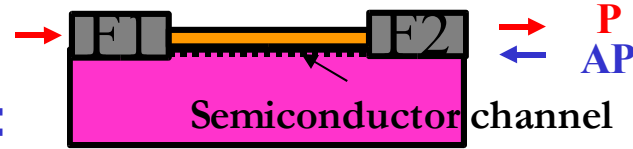
« Measured effects of the order of **0.1-1%** have been reported for the change in

voltage or resistance (between **P** and **AP**).... », *from the review article*

« *Electrical Spin Injection and Transport in Semiconductors* » by **BT Jonker**

and **ME Flatté** in *Nanomagnetism* (ed.: **DL Mills** and **JAC Bland**, Elsevier 2006)

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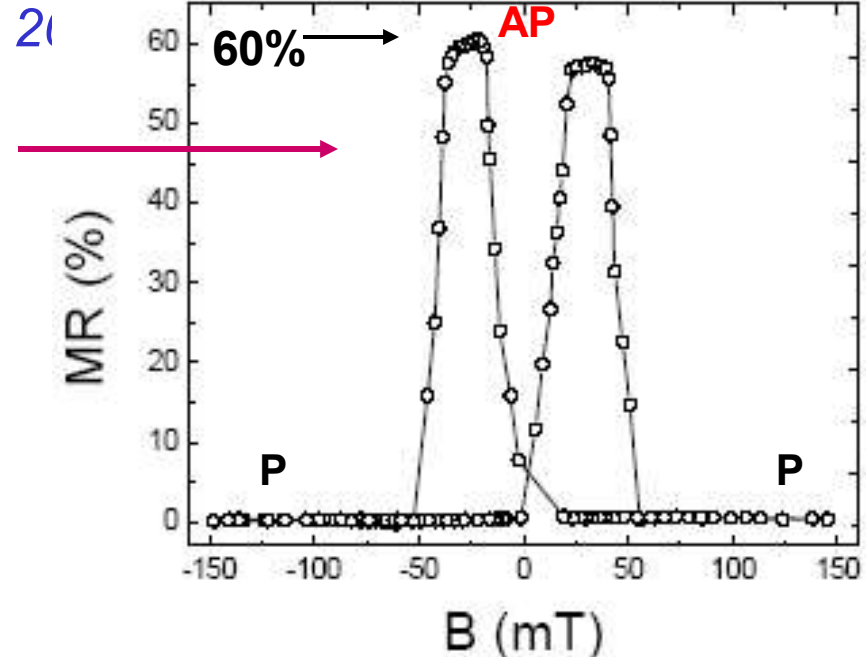
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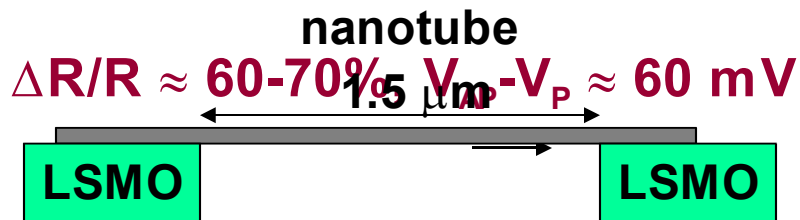
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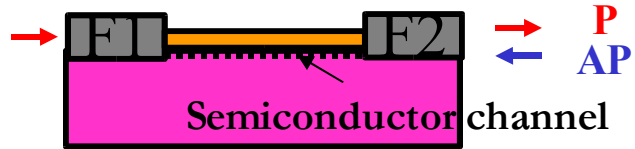
El-Hessei, M.D. Mathur, A.F. et al, Nature 445, 416, 2007



Carbon nanotubes:



Nonmagnetic lateral channel between spin-polarized source and drain



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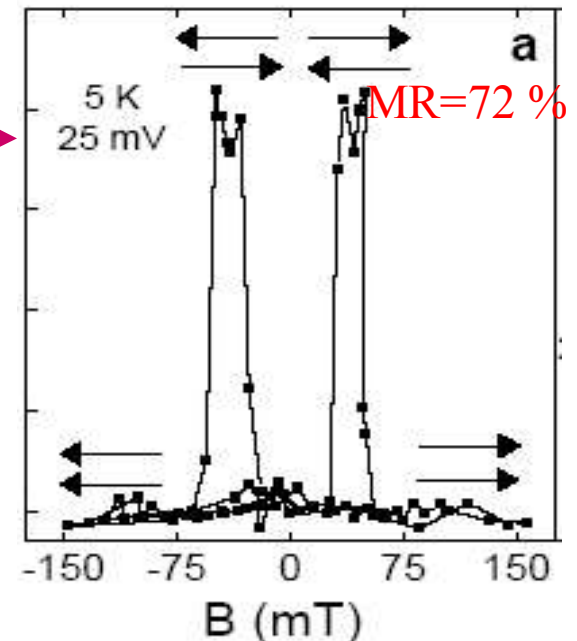
« *Electrical Spin Injection and Transport in Semiconductors* » by **BT Jonker**

and **ME Flatté** in *Nanomagnetism* (ed. **DL Mills** and **JG Blak**, Elsevier, 2006)

E. Hueso, N.D. Mathur, A.F. et al, Nature 445, 410, 2007

Carbon nanotubes:

nanotube
 $\Delta R/R \approx 60-70\%$ $V_m - V_p \approx 60 \text{ mV}$
 $1.5 \mu\text{m}$

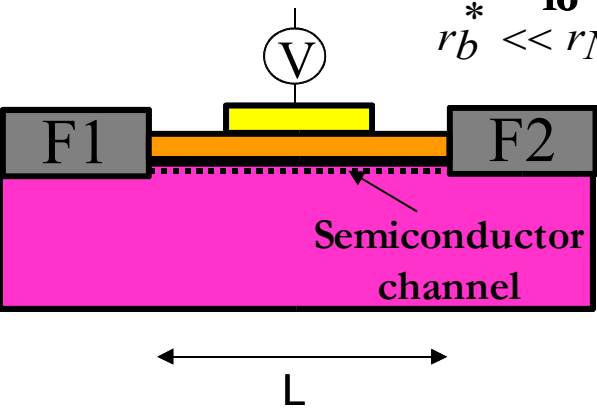
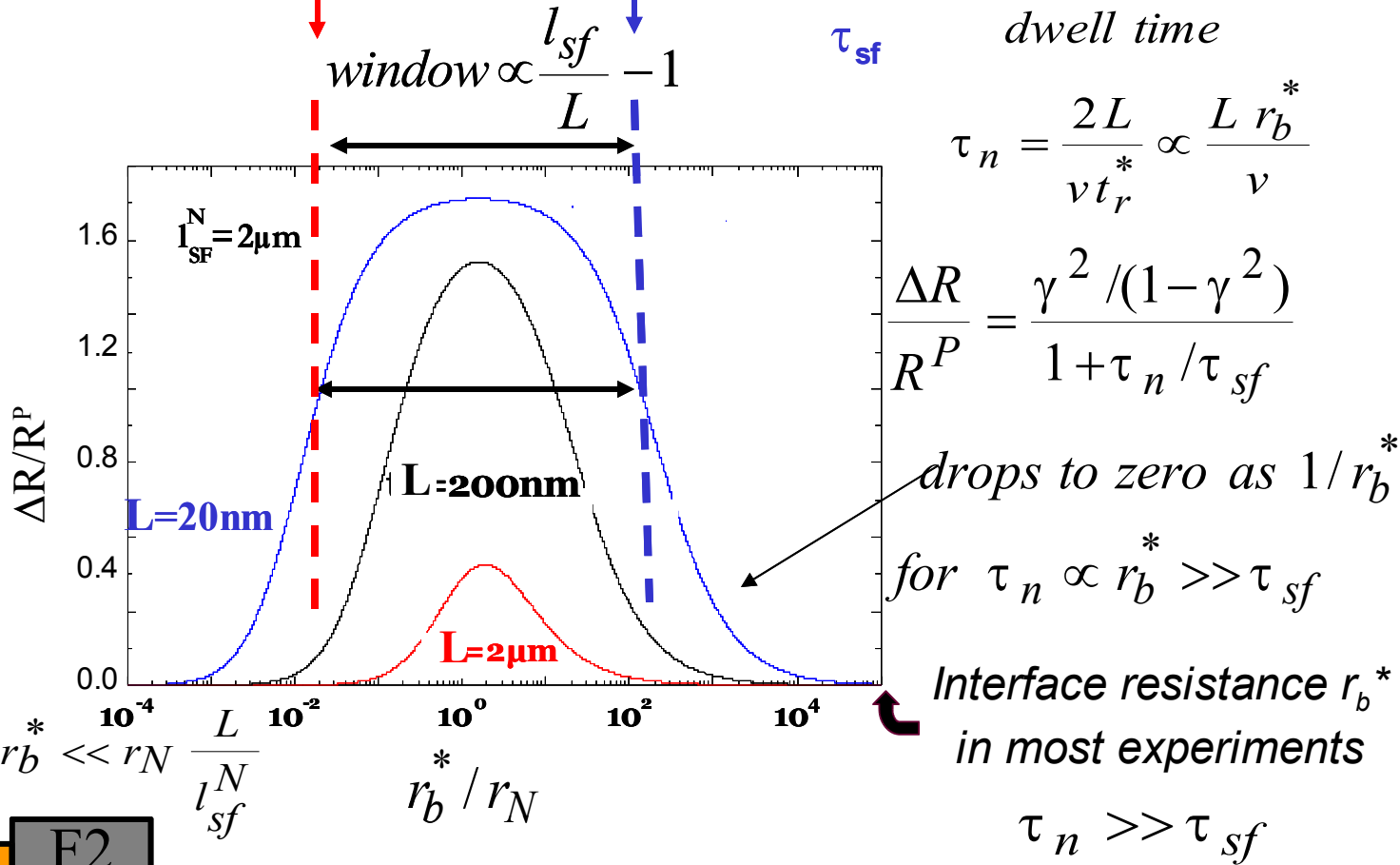


Two interface spin transport problem (diffusive regime)

AF and Jaffrès
PR B 2001
+cond-mat
0612495, +
IEEE Tr.El.Dev.
54,5,921,2007

Condition for spin injection

Condition
dwell time $\tau_n <$ spin lifetime



r_b^* = unit area interface resist. $\propto 1/\text{trans.co eff } t_r^*$

γ = spin asymmetry of the interface resistance

$$r_N = \rho_N l_{sf}^N$$

Transport between SP source and drain : τ_n = dwell time, τ_{sf} = spin lifetime, γ = injection SP

: the contrast between P (on) and AP (off), $\frac{\Delta R}{R^P} = \frac{\gamma^2 / (1 - \gamma^2)}{1 + \tau_n / \tau_{sf}}$, is large if $\tau_n < \tau_{sf}$

Nanotubes (also graphene, other molecules) :

small spin - orbit \rightarrow spin lifetime τ_{sf} is long (≈ 50 ns)

high velocity $v \rightarrow \tau_n = \frac{2L}{v\bar{t}_r}$ is short ($< \tau_{sf}$)

Semiconductor

s: τ_{sf} can be long (for $n \approx 10^{17}$ el / cm³)

but v is small $\rightarrow \tau_n = \frac{2L}{v\bar{t}_r}$ is long ($\gg \tau_{sf}$)

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Solution for semiconductors:

shorter L ?, larger transmission

t_r ?

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Potential of molecular spintronics (nanotubes, graphene and others)

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**Solution for semiconductors:
shorter L ?, larger transmission**

\bar{t}_r ?

**Potential of molecular
spintronics (nanotubes,
graphene and others)**

**Next challenge for molecules:
spin control by gate**

Summary

α Already important applications of GMR/TMR (HDD, MRAM..) and now promising new fields

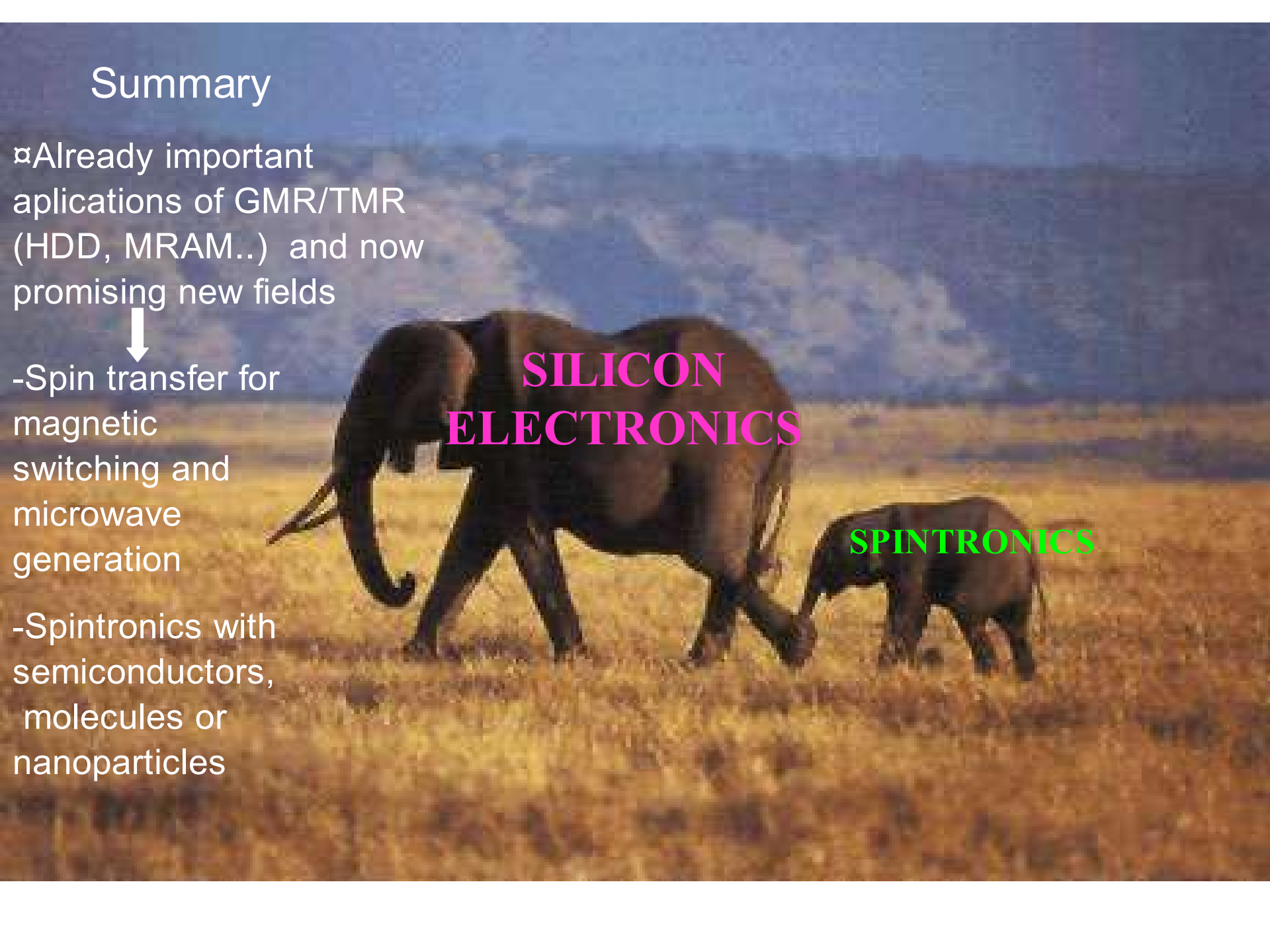


-Spin transfer for magnetic switching and microwave generation

-Spintronics with semiconductors, molecules or nanoparticles

**SILICON
ELECTRONICS**

SPINTRONICS



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